

EDA复合物在电子转移过程中的应用

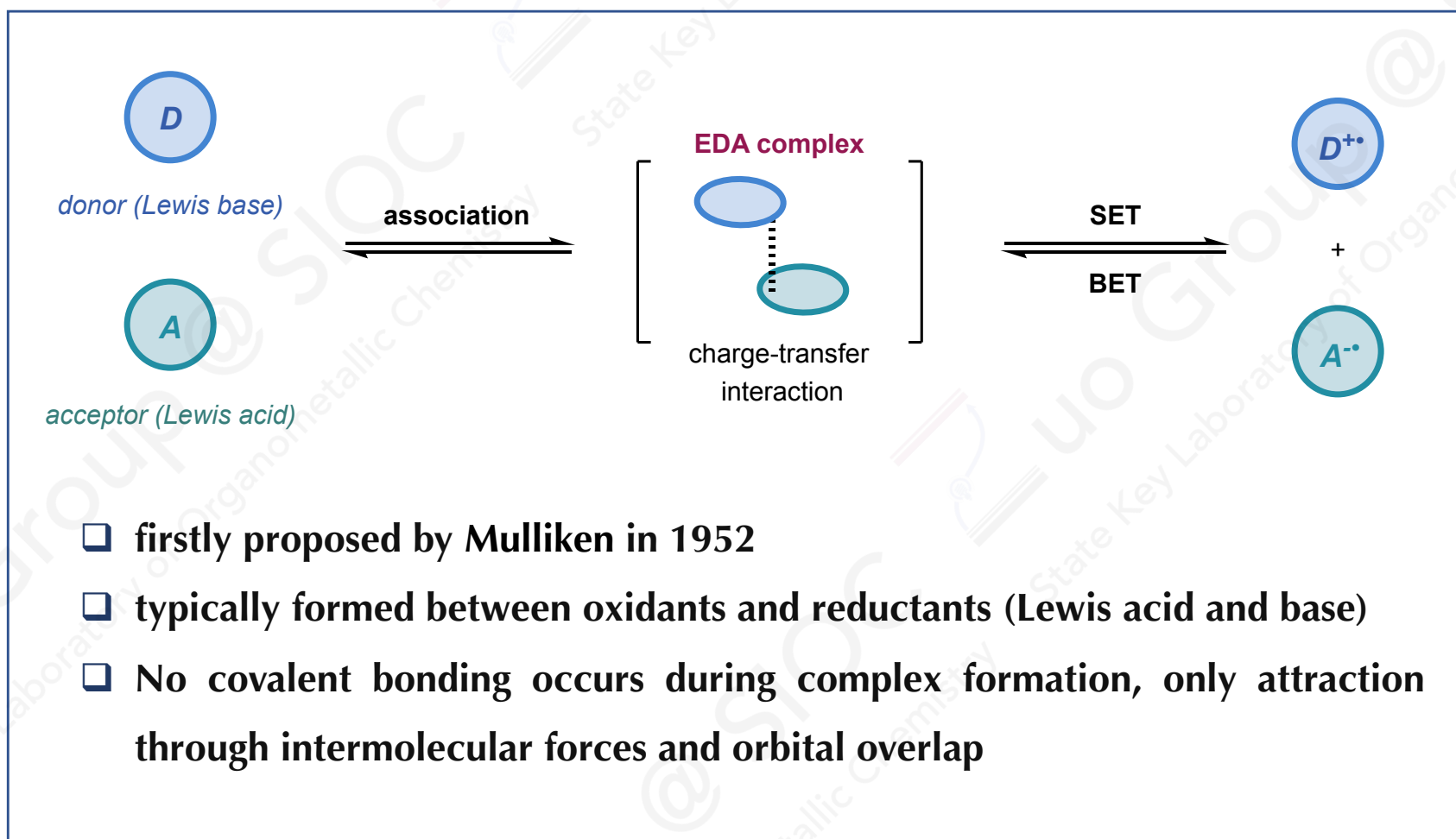
汇报人：段凌霏

导师：左智伟 研究员

2023.12.1

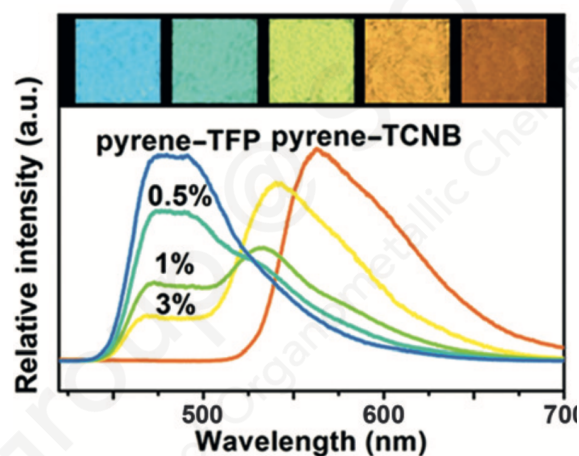
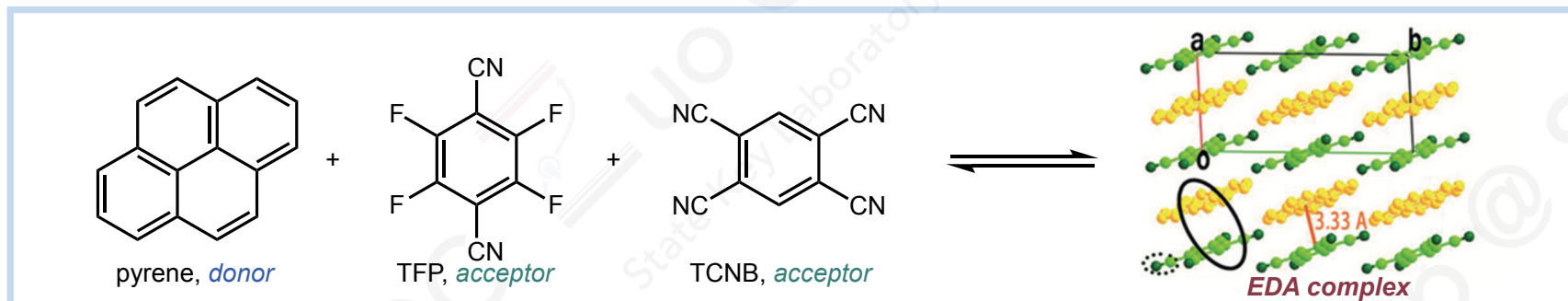
Electron donor acceptor complex (EDA complex)

The association of an electron-rich substrate with an electron-accepting molecule can generate a new molecular aggregate in the ground state.



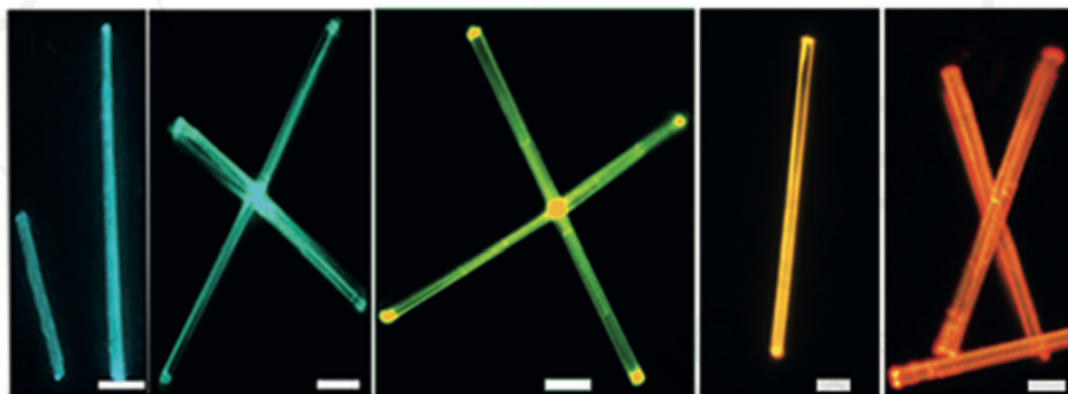
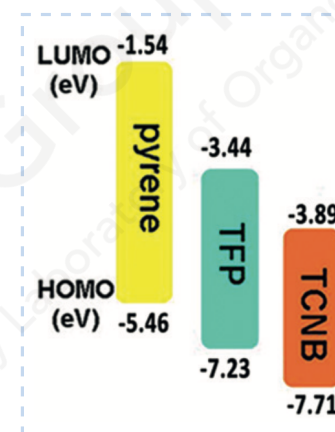
EDA复合物电子转移过程在材料中的应用

■ Charge-Transfer Interactions in Organic Light-Harvesting Systems



➤ 通过共结晶方式得到掺杂不同比例TCNB的EDA复合物

➤ 掺杂不同比例TCNB的EDA复合物产生不同EDA band



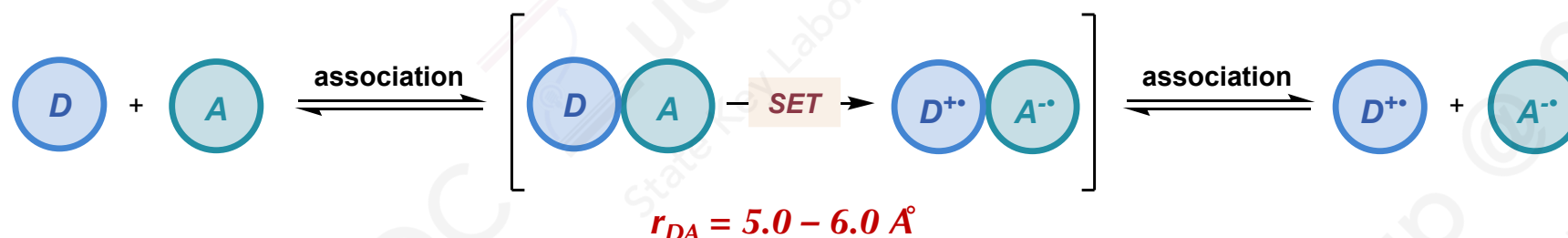
光致发光材料

➤ 荧光发射光谱取决于TCNB掺杂比例

Hu, W. et al. *Angew. Chem. Int. Ed.* 2017, 56, 10352–10356.

电子转移过程的分类

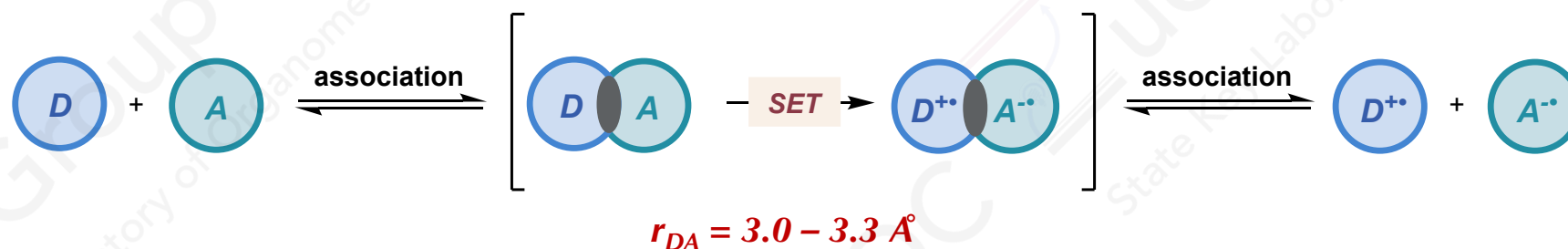
Outer Sphere Electron Transfer



➤ 电子转移步为决速步

➤ 非绝热过程

Inner Sphere Electron Transfer



➤ 电子转移步可能不是决速步

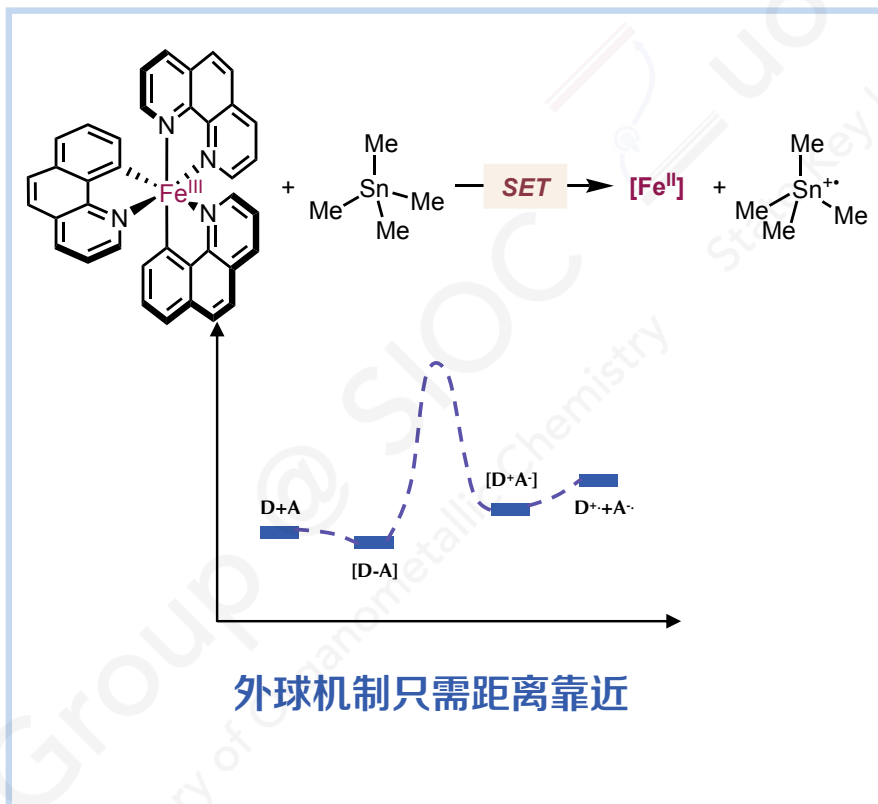
➤ 绝热过程

Paixaõ, M.W. et al. *ACS catal.* **2016**, 6, 1389–1407.

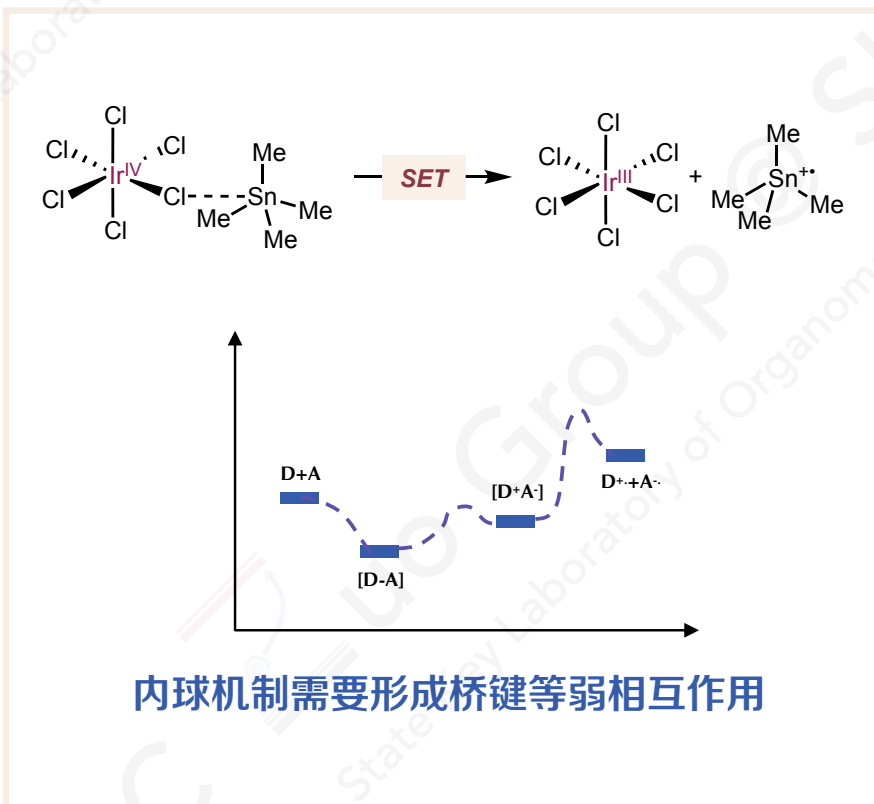
❑ EDA复合物通常发生内球电子转移反应

电子转移过程的分类

Outer Sphere Electron Transfer



Inner Sphere Electron Transfer

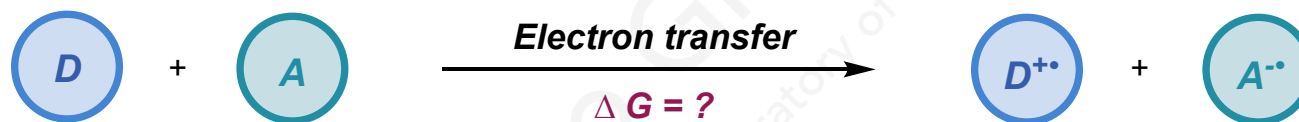


形成EDA复合物后其偶极矩、溶解度、电导率和晶体结构等变化都可能影响电子转移

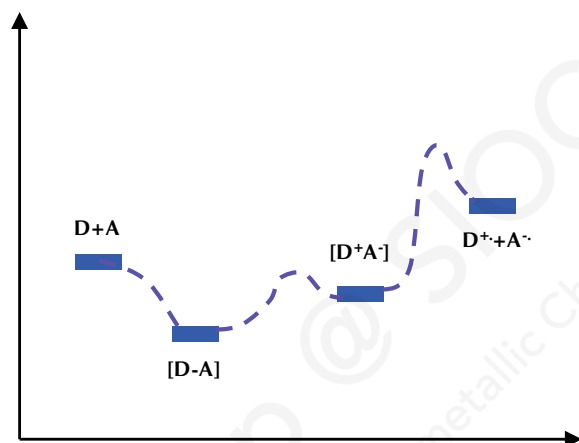
评估EDA复合物性质: X射线晶体衍射

- ❑ 评估D和A的哪些轨道用于CT稳定
- ❑ 提供了D-A距离, 与范德华半径和共价键距离进行比较
- ❑ 评估D和A内部结构的变化

EDA复合物电子转移过程中的热力学研究



□ 根据能斯特方程计算反应自由能

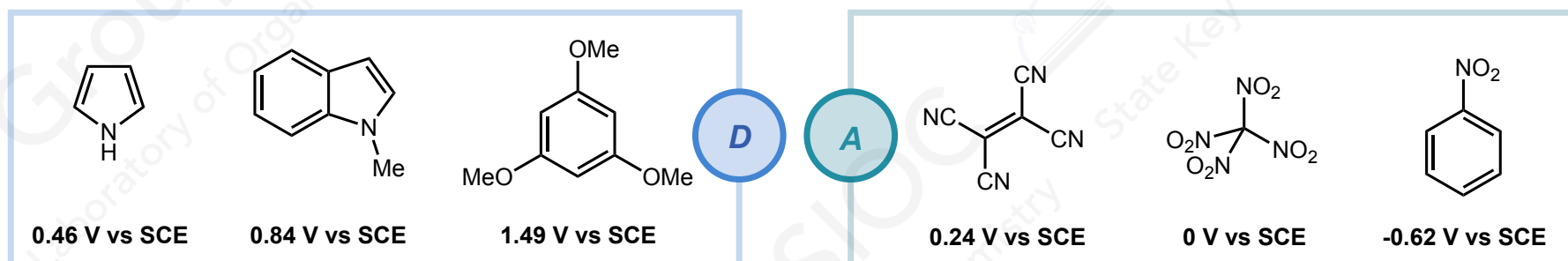


$$\Delta_{\text{et}} G^{\circ} = N_{\text{A}} [e(E^0(\text{D}^{\bullet+}/\text{D}) - E^0(\text{A}/\text{A}^{\bullet-})) + w(\text{D}^{\bullet+}, \text{A}^{\bullet-}) - w(\text{D}, \text{A})] - \Delta E_{0,0}$$

$$E^0(\text{D}^{\bullet+}/\text{D}) - E^0(\text{A}/\text{A}^{\bullet-}) : E_{\text{red}}^0(\text{A}) - E_{\text{red}}^0(\text{D})$$

$$w(\text{D}^{\bullet+}, \text{A}^{\bullet-}) - w(\text{D}, \text{A}) : \text{电荷分离功}$$

$$\Delta E_{0,0} : \text{EDA复合物基态到激发态能量}$$

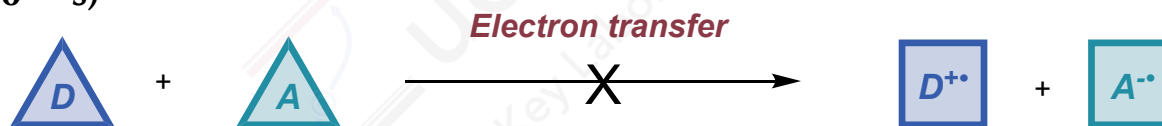


Kochi, J. K. et al. *J. Am. Chem. Soc.* **1997**, 119, 9393–9404.

EDA复合物电子转移反应是否发生？什么条件能够激发电子转移反应？

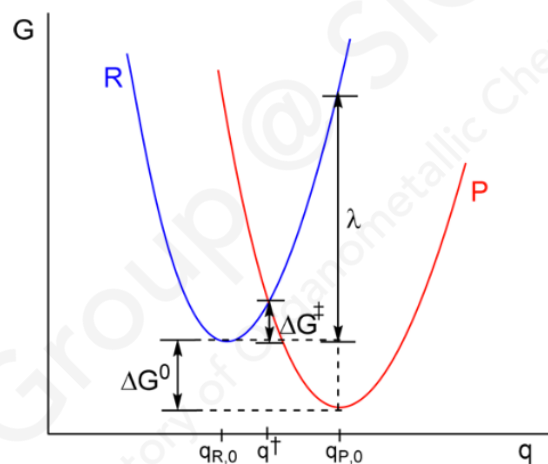
电子转移过程中的动力学研究

- Franck-Condon principle : Electronic transitions ($\sim 10^{-16}$ s) are much faster than nuclear vibrations ($\sim 10^{-13}$ s)



Eyring transition state theory 预测势能面和结构的关系在电子转移反应中不适用

Outer Sphere Electron Transfer



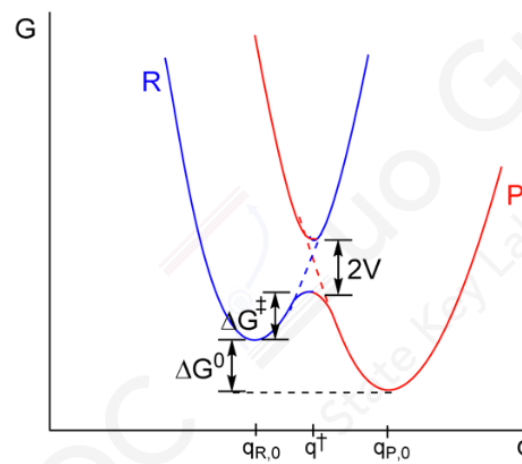
电子转移:
势能面发生切换

λ : 垂直跃迁能量

$V \sim 100-300 \text{ cm}^{-1}$

$$\Delta G^{\ddagger} = \lambda/4$$

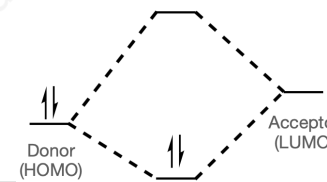
Inner Sphere Electron Transfer



V : 电子耦合值

$V \sim 1000-3000 \text{ cm}^{-1}$

$$\Delta G^{\ddagger} = (\lambda - 2V)^2/(4\lambda)$$

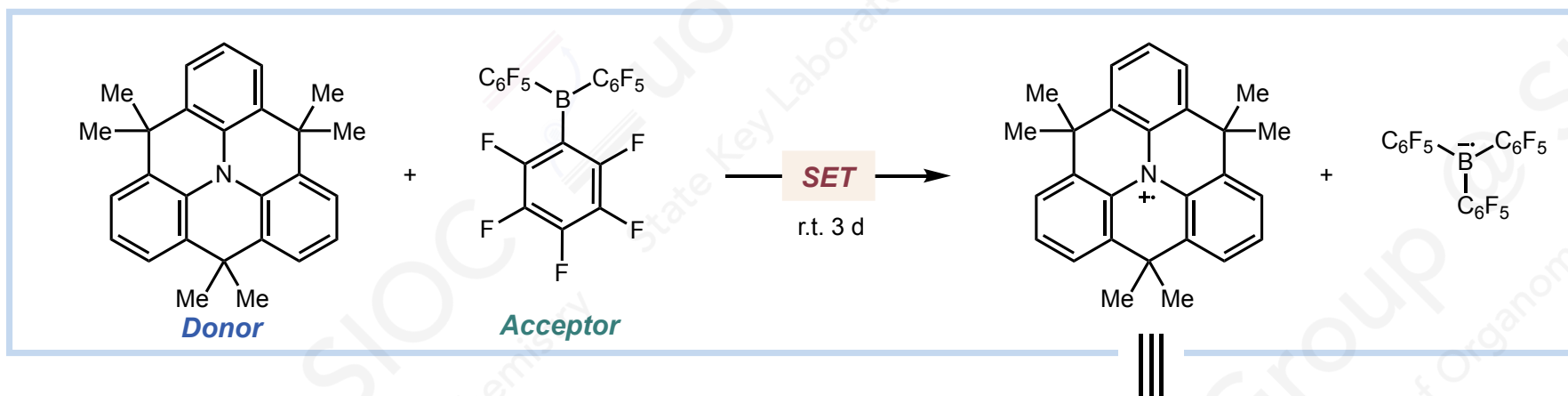


Kochi, J. K. et al. *Acc. Chem. Res.* **2008**, *41*, 641–653.

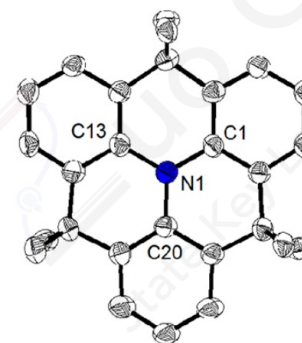
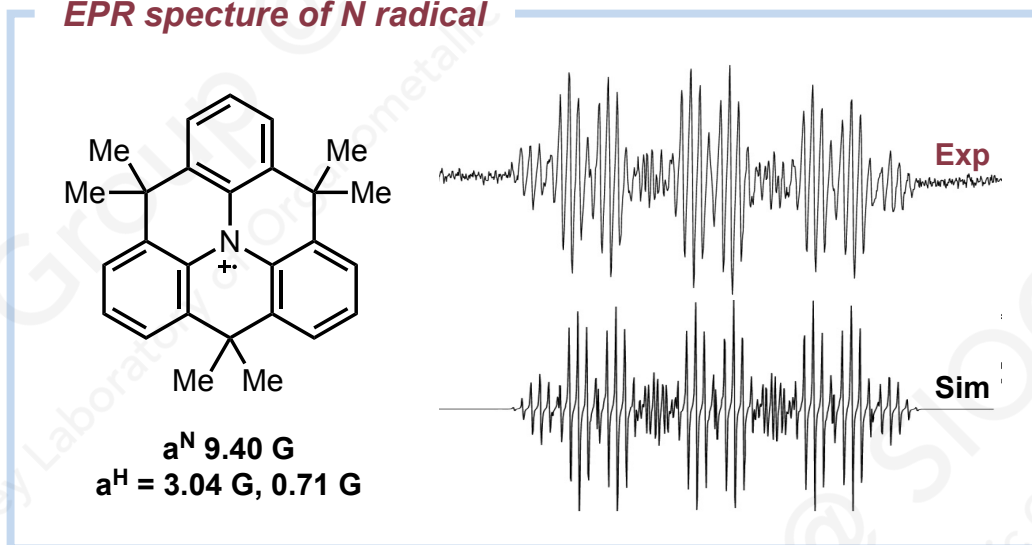
❑ EDA复合物电子转移动力学还与D、A本身性质， π 体系大小，溶剂化等因素有关

EDA复合物的激发模式

□ 加热条件激发EDA复合物电子转移



EPR spectre of N radical



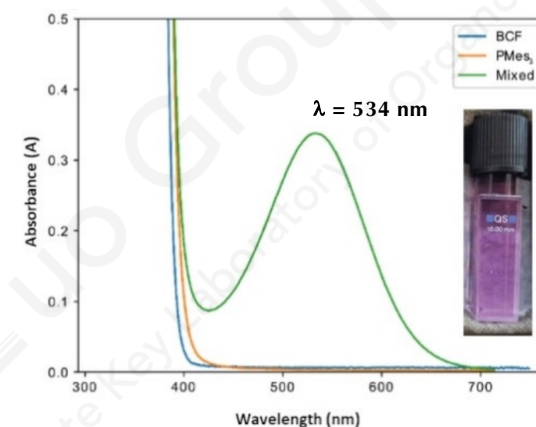
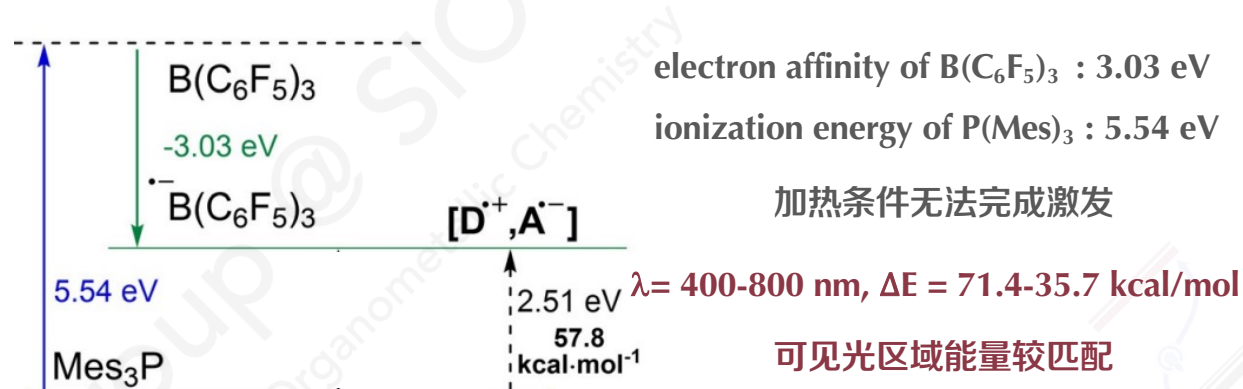
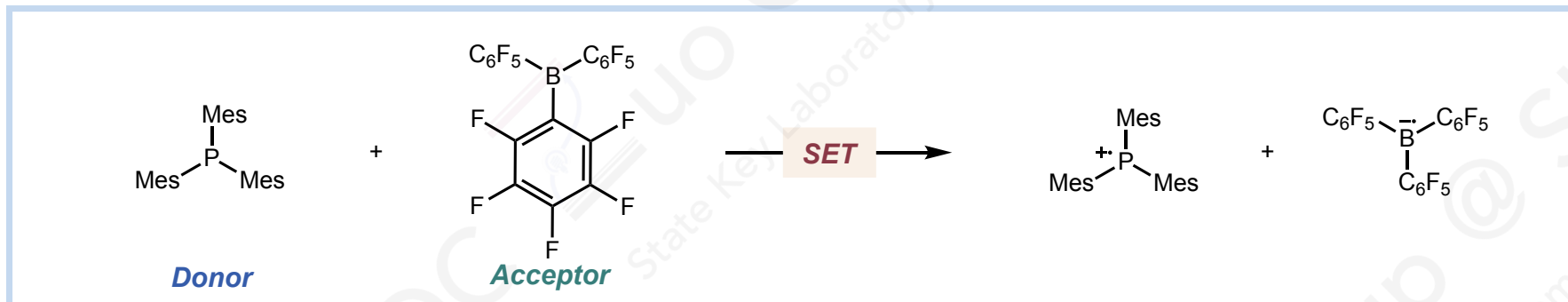
首个EDA复合物
发生单电子转移
的直接实验证据

electron affinity of $\text{B}(\text{C}_6\text{F}_5)_3$: 3.03 eV
ionization energy of donor : 3.30 eV

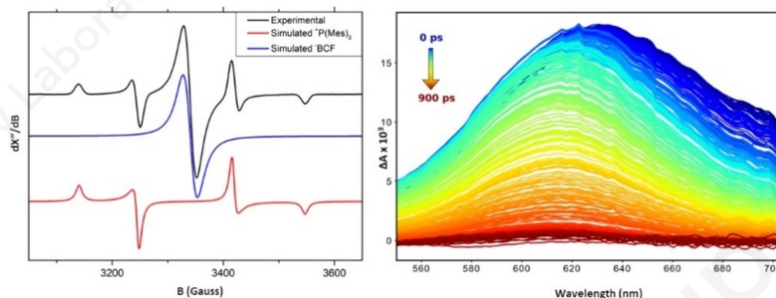
Wang, X. et al. *J. Am. Chem. Soc.* **2013**, 135, 14912–14915.

EDA复合物的激发模式

□ 光照条件激发EDA复合物电子转移



EPR and TA spectre



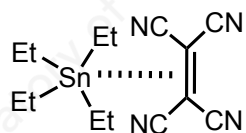
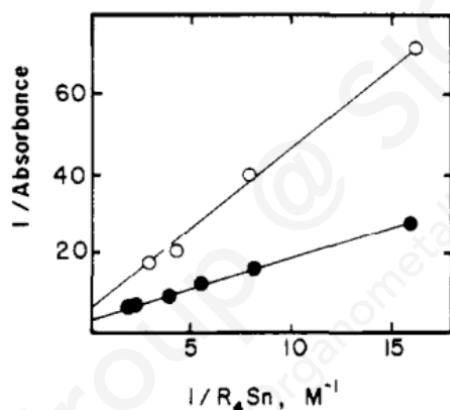
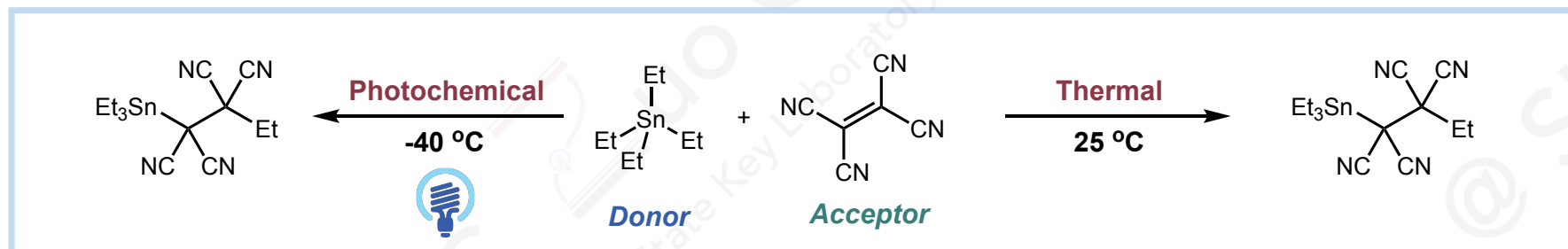
EPR : 颜色变化来自EDA复合物的形成而不是产生自由基

TA : lifetime of the radical ion $\text{P}(\text{Mes})_3/\text{B}(\text{C}_6\text{F}_5)_3$: 6 ps

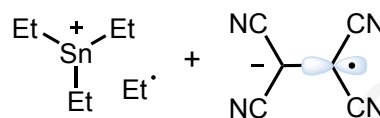
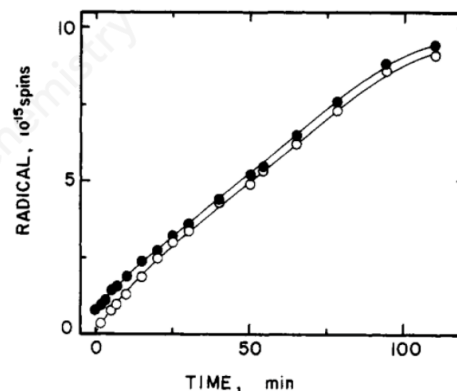
SET之后发生快速的BET, 绝大多数平衡于EDA复合物一侧

EDA复合物的激发模式

光照与加热条件激发过程比较



➤ UV-vis光谱证明EDA复合物加和比例为1:1



➤ 低温EPR实验证明两种自由基以相同的速率生成

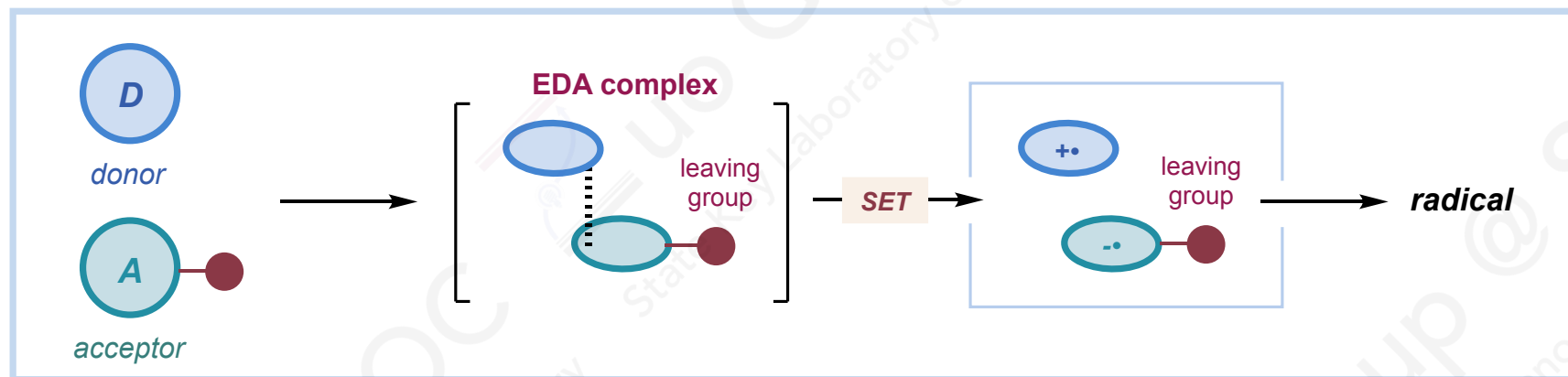
Organotin	Method	Product Ratio (Et:Me)
	Thermal	7:1
	Photo.	7:1
	Thermal	11:1
	Photo.	11:1

➤ 使用不同有机锡试剂时，不同激发模式得到相同选择性产物

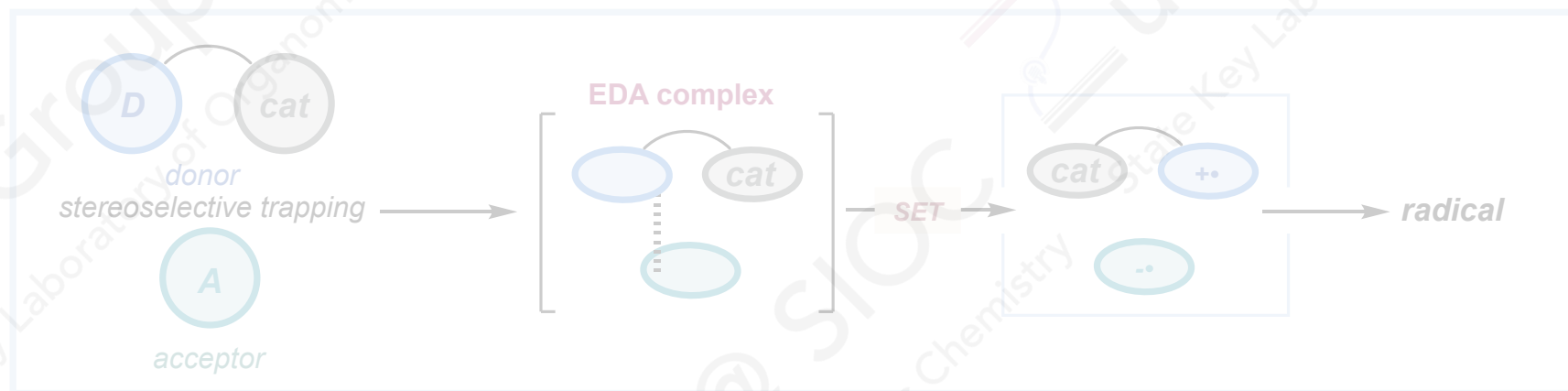
Kochi, J. K. et al. *J. Am. Chem. Soc.* **1979**, *101*, 5961-5972.

EDA复合物热激发和光激发电子转移经历相同机理

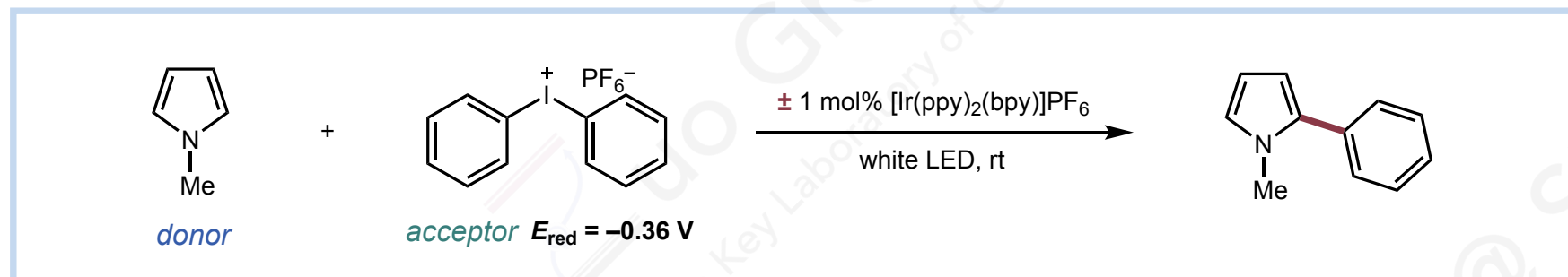
一、化学计量EDA电子转移反应



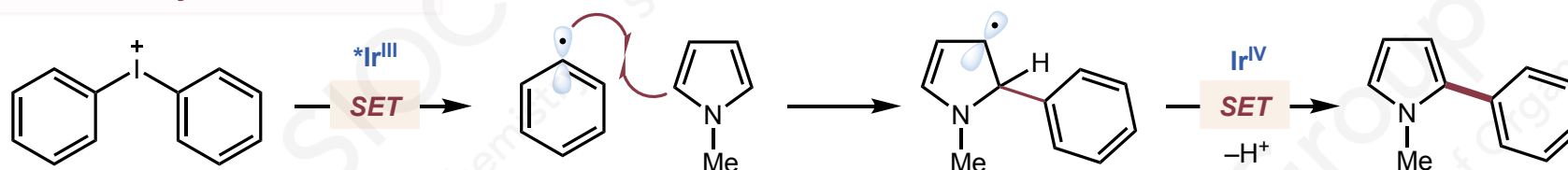
二、催化EDA电子转移反应



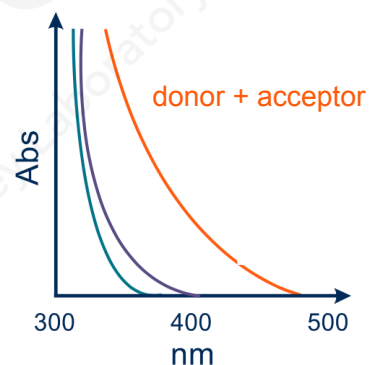
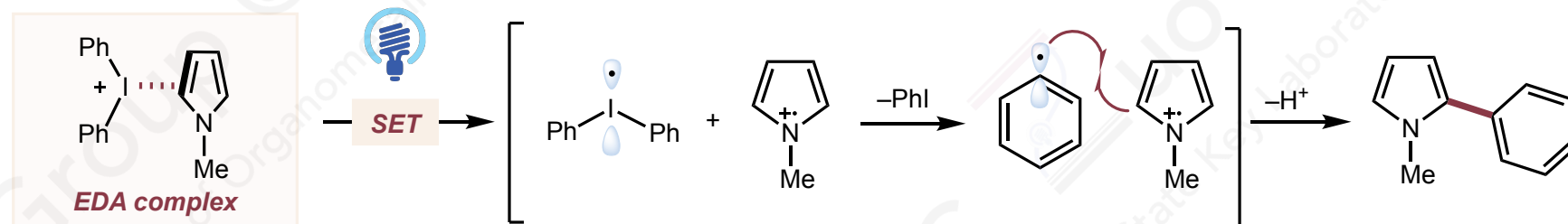
Stoichiometric EDA complex: C–C Bond formation

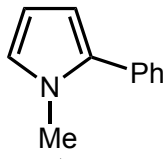
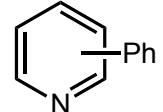


Photocatalytic Mechanism



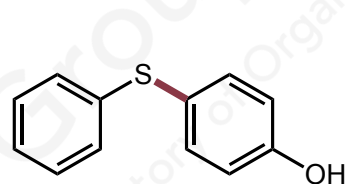
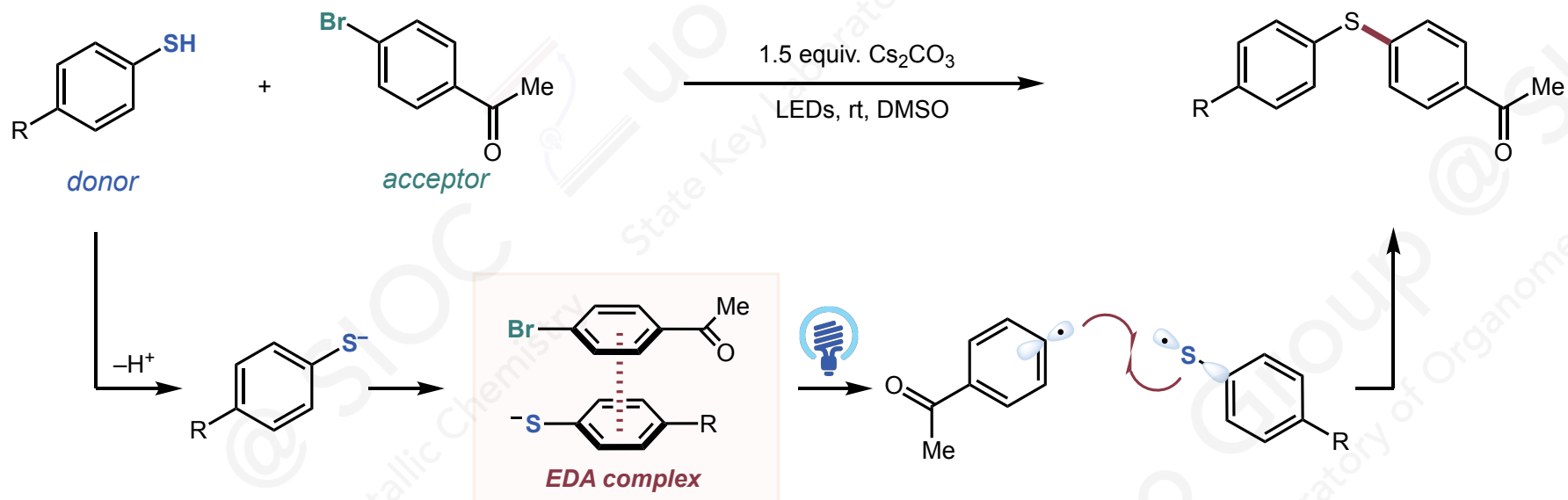
EDA Mechanism



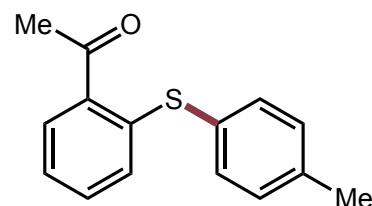
	with $[\text{Ir}(\text{ppy})_2(\text{bpy})]\text{PF}_6$	without $[\text{Ir}(\text{ppy})_2(\text{bpy})]\text{PF}_6$
 $\text{E}_{\text{ox}} = 1.2 \text{ V}$	88% yield	54% yield
 $\text{E}_{\text{ox}} = 1.8 \text{ V}$	57% yield (54:30:16)	9% yield (56:44:0)

Stoichiometric EDA complex: C–S Bond formation

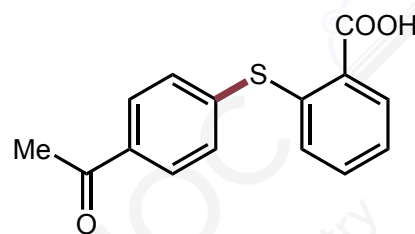
Visible-Light-Promoted C–S Cross-Coupling via Intermolecular Charge Transfer



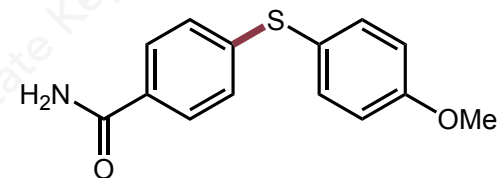
25% yield



X = I, 76% yield, 1 h
X = Cl, 82% yield, 12 h



64% yield

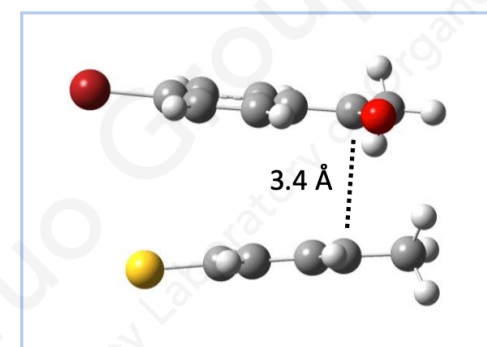
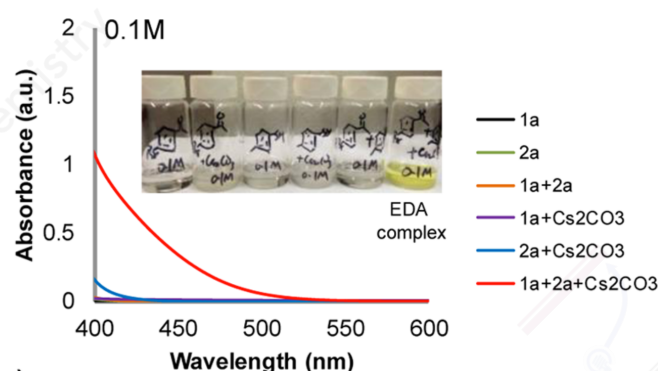
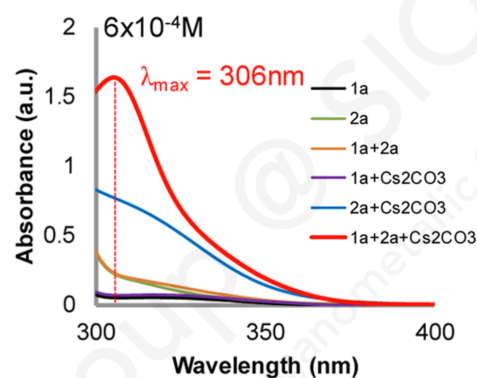
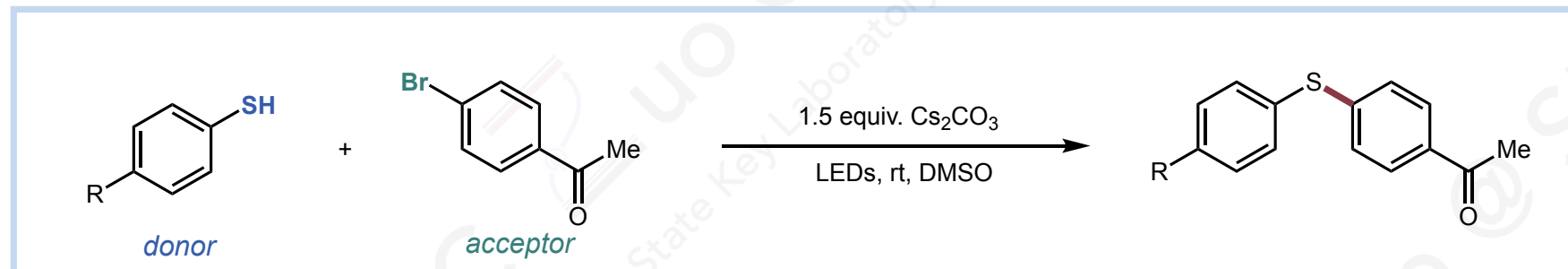


80% yield

Miyake, G. M. et al. *J. Am. Chem. Soc.* **2017**, *137*, 13616-13619.

Stoichiometric EDA complex: C–S Bond formation

Visible-Light-Promoted C–S Cross-Coupling via Intermolecular Charge Transfer



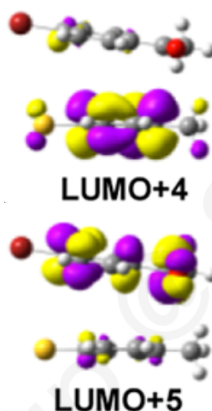
$\lambda = 282 nm$

35 % $\pi HOMO-\pi LUMO_{+4}$

硫醇负离子自身跃迁

32 % $\pi HOMO-\pi LUMO_{+5}$

EDA复合物跃迁

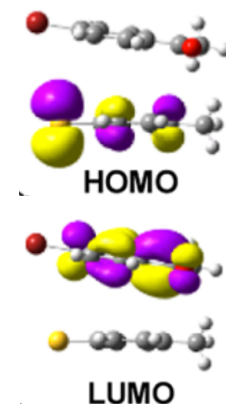


$\lambda = 383 nm$

98 % $\pi HOMO-\pi LUMO$

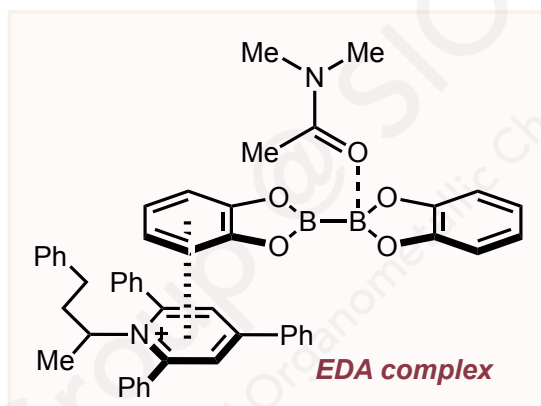
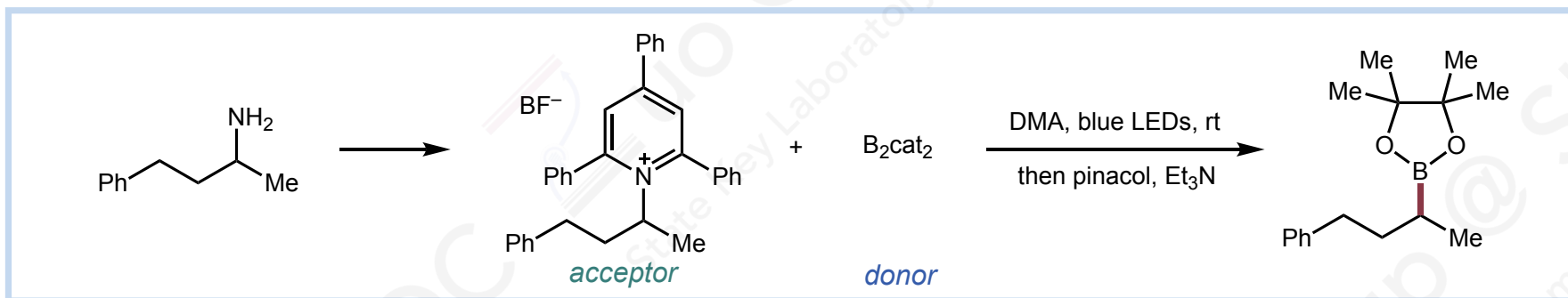
EDA复合物跃迁

产生可见光区吸收主要原因

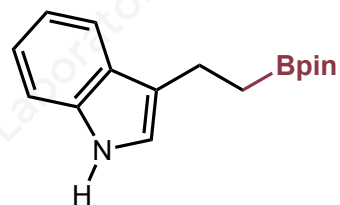
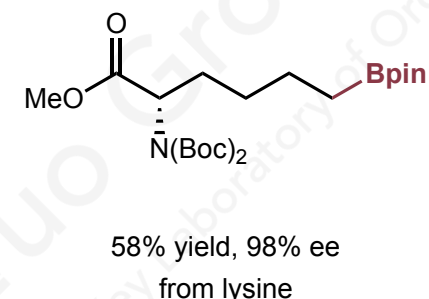


Stoichiometric EDA complex: C–B Bond formation

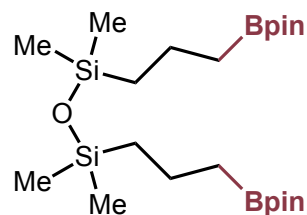
■ Photoinduced Deaminative Borylation of Alkylamines



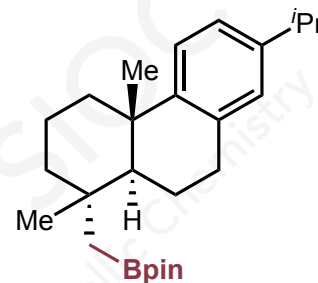
modifications	yield
none	89 %
no light	35 %
no light, 65 °C	72 %



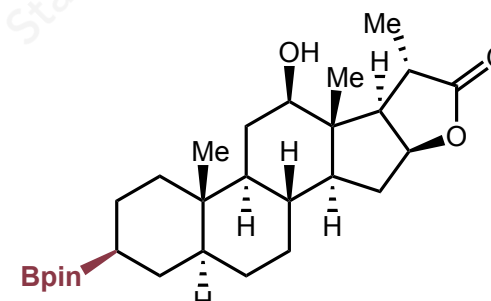
52% yield



64% yield



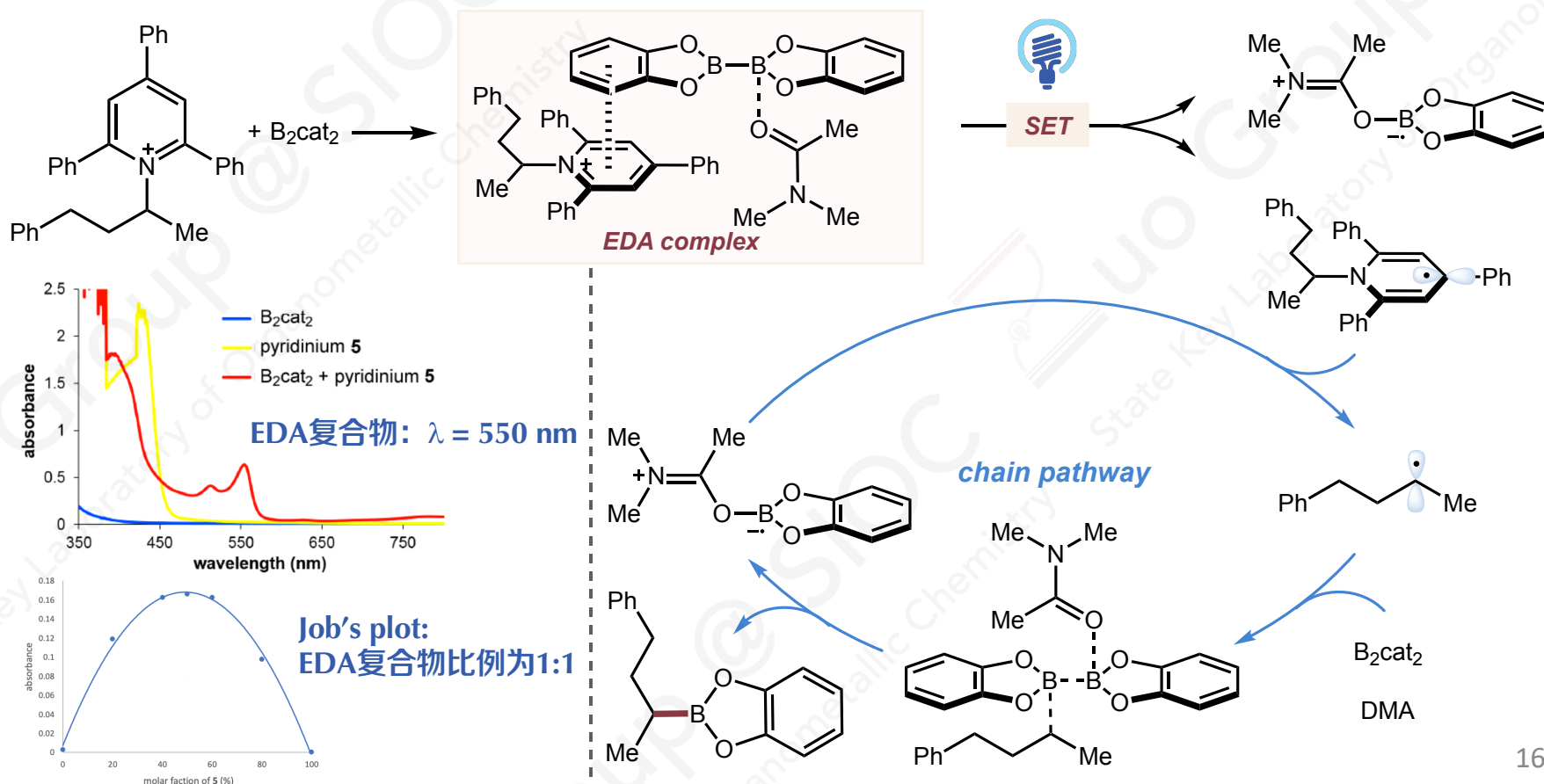
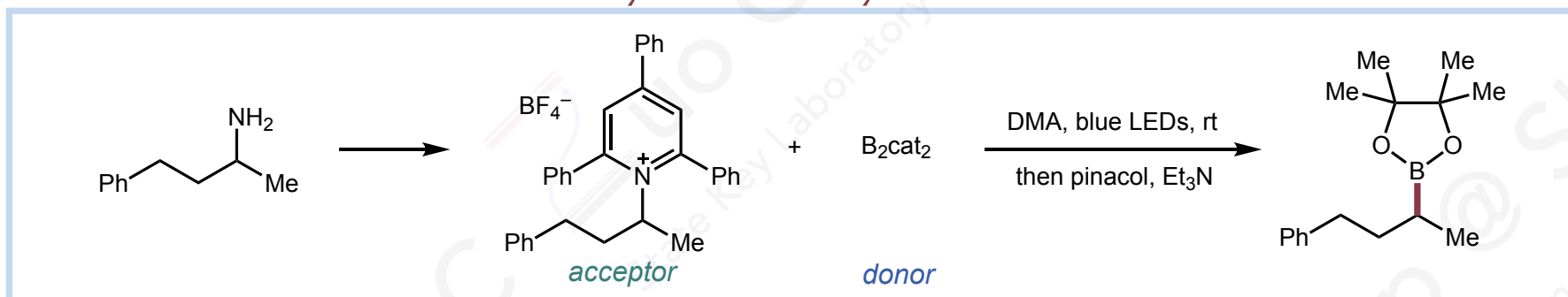
55% yield from leelamine



76% yield, 95:5 d.r. from hecogenin

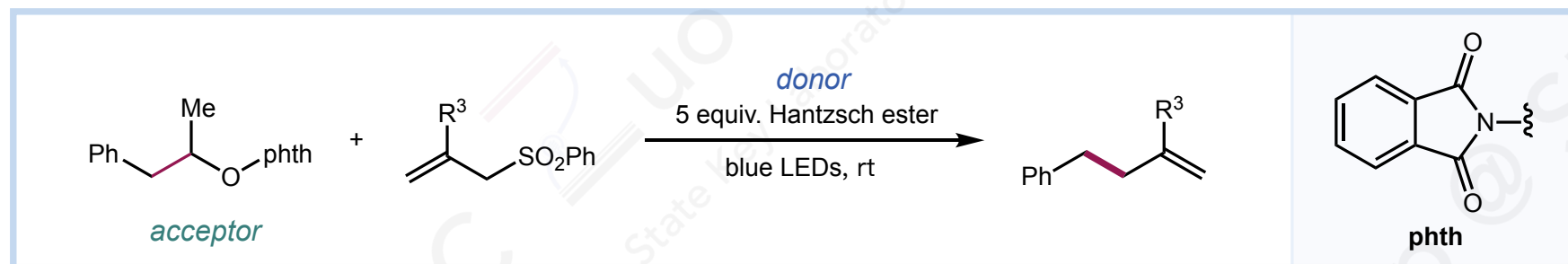
Stoichiometric EDA complex: C–B Bond formation

■ Photoinduced Deaminative Borylation of Alkylamines

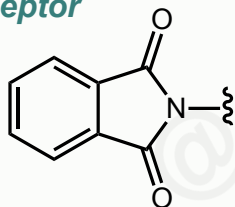


Stoichiometric EDA complex: C–C Bond formation

EDA Complex Enables Alkoxy Radical Generation for C(sp³)–C(sp³) Cleavage

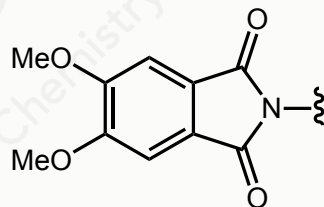


acceptor



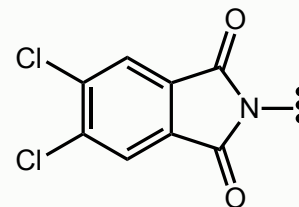
$E_{\text{red}} = -1.40 \text{ V (SCE)}$

72% yield, >95% conversion



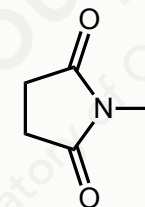
$E_{\text{red}} = -1.50 \text{ V (SCE)}$

64% yield, 70% conversion



$E_{\text{red}} = -1.19 \text{ V (SCE)}$

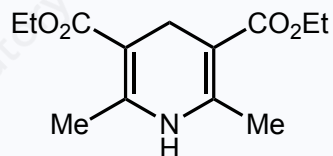
66% yield, >95% conversion



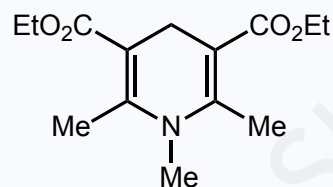
$E_{\text{red}} = -0.98 \text{ V (SCE)}$

<5% yield, <5% conversion

donor



67% yield, 79% conversion



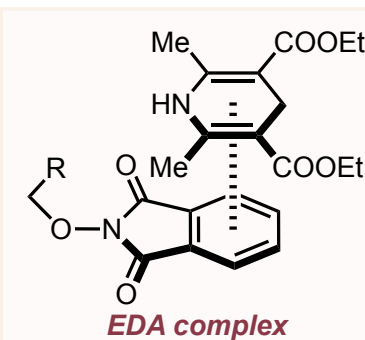
<5% yield, <5% conversion

no light: <5% yield

no light, 50 °C: 28% yield

450 nm LED: 70% yield

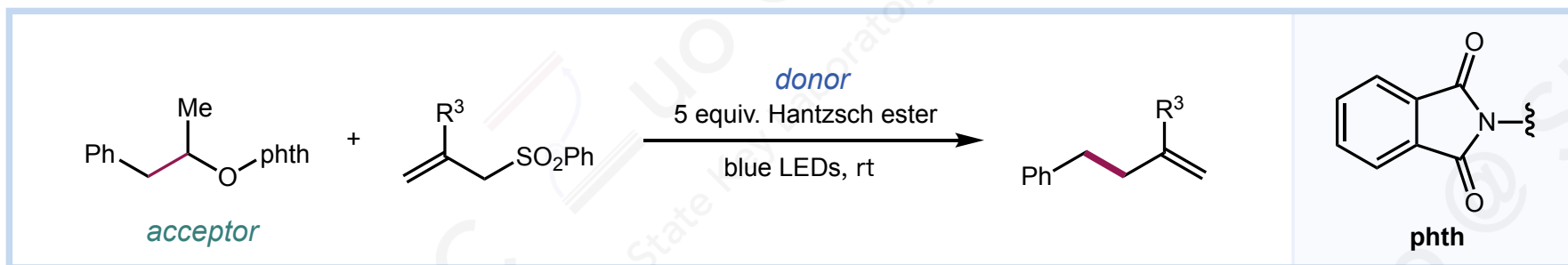
475 nm LED: 37% yield



Chen, Y. et al. *Angew. Chem. Int. Ed.* **2017**, 56, 12619–12623.

Stoichiometric EDA complex: C–C Bond formation

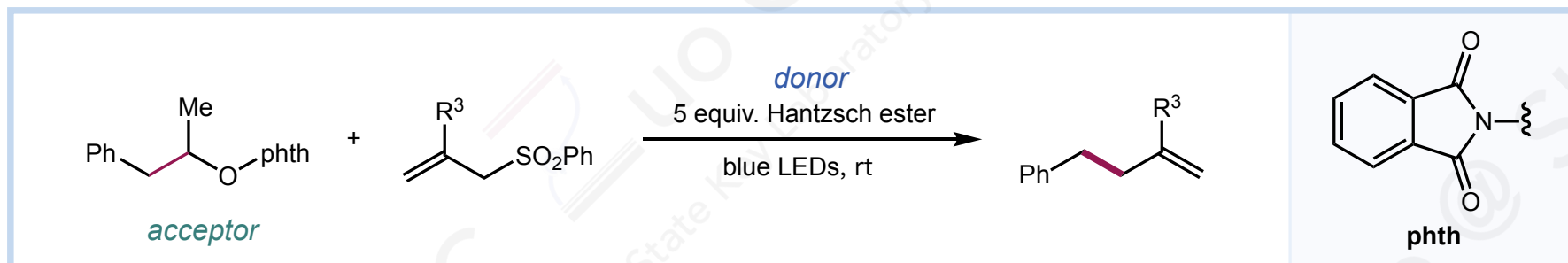
■ EDA Complex Enables Alkoxy Radical Generation for C(sp³)–C(sp³) Cleavage



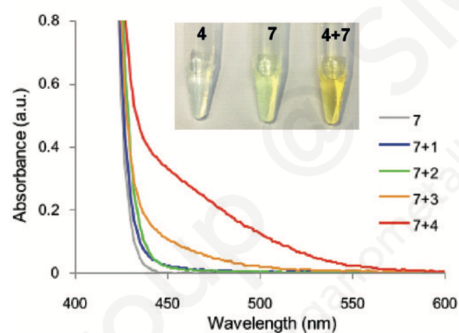
Starting material	Product	Starting material	Product	Starting material	Product
	 61% yield		 53% yield		 64% yield
	 71% yield		 88% yield		 88% yield

Stoichiometric EDA complex: C–C Bond formation

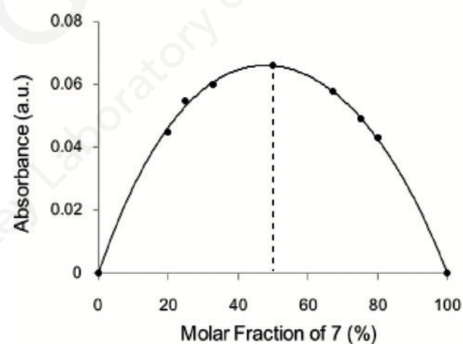
EDA Complex Enables Alkoxy Radical Generation for $C(sp^3)$ – $C(sp^3)$ Cleavage



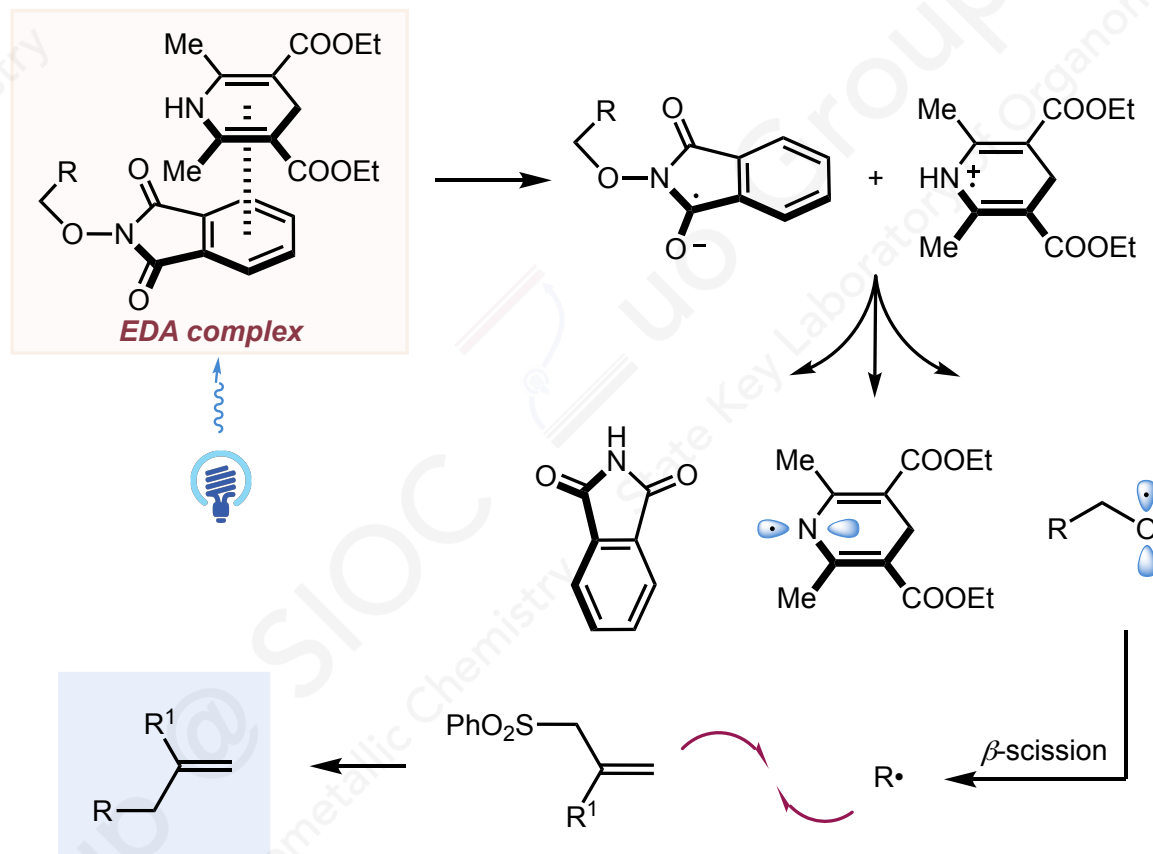
proposed mechanism



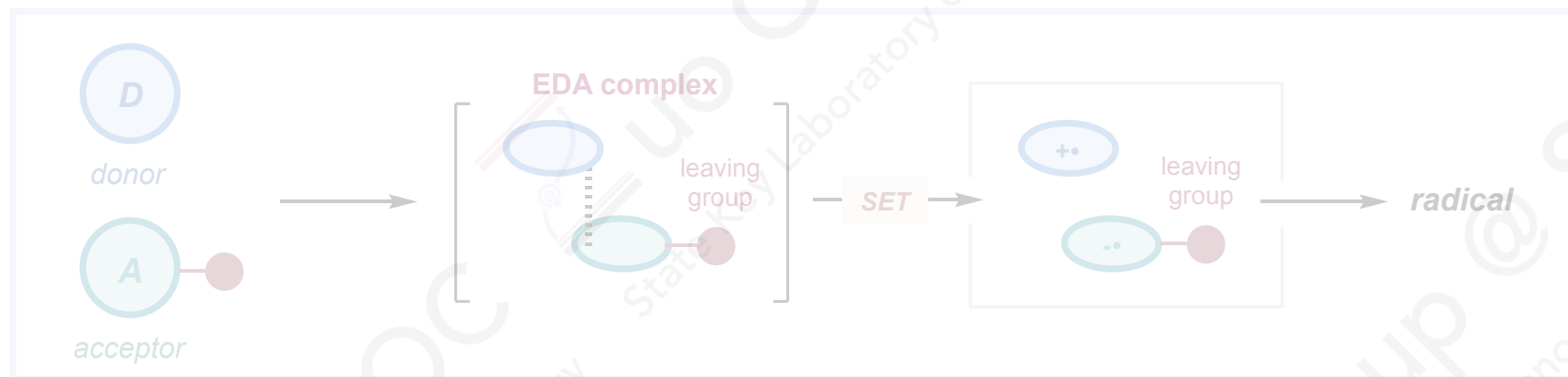
EDA band: $\lambda = 450$ nm



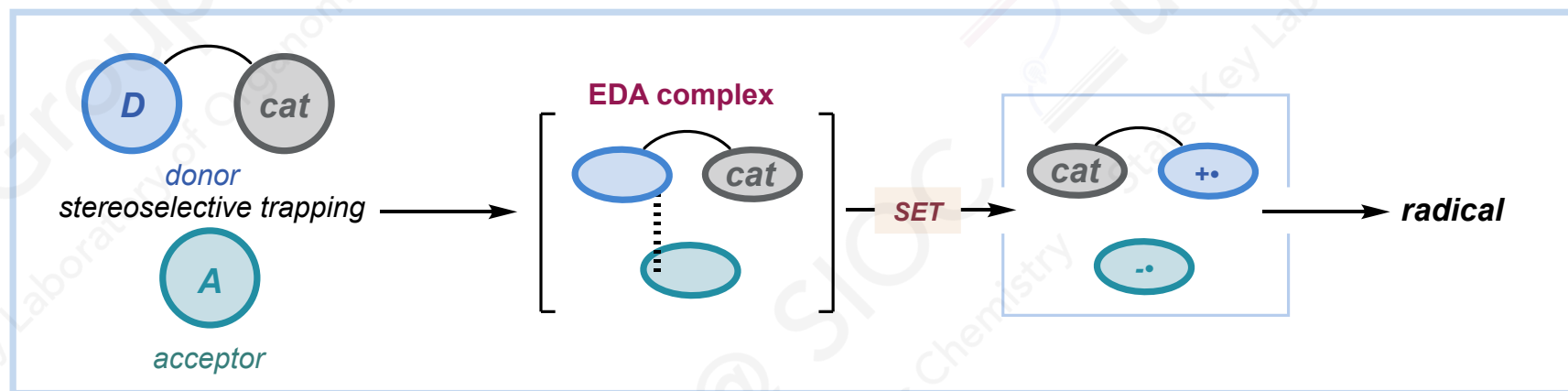
EDA ratio: 1:1



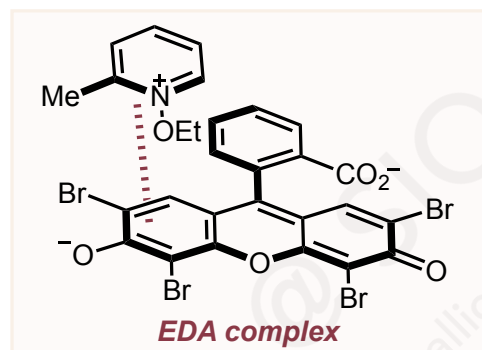
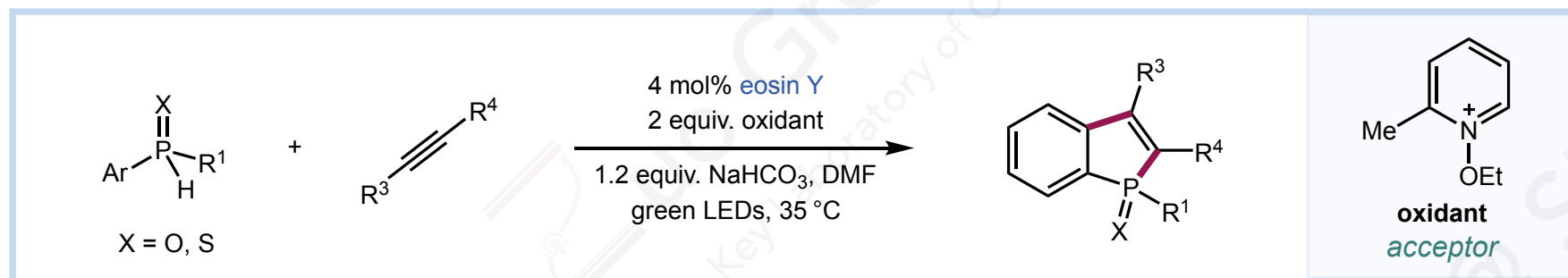
一、化学计量EDA电子转移反应



二、催化EDA电子转移反应



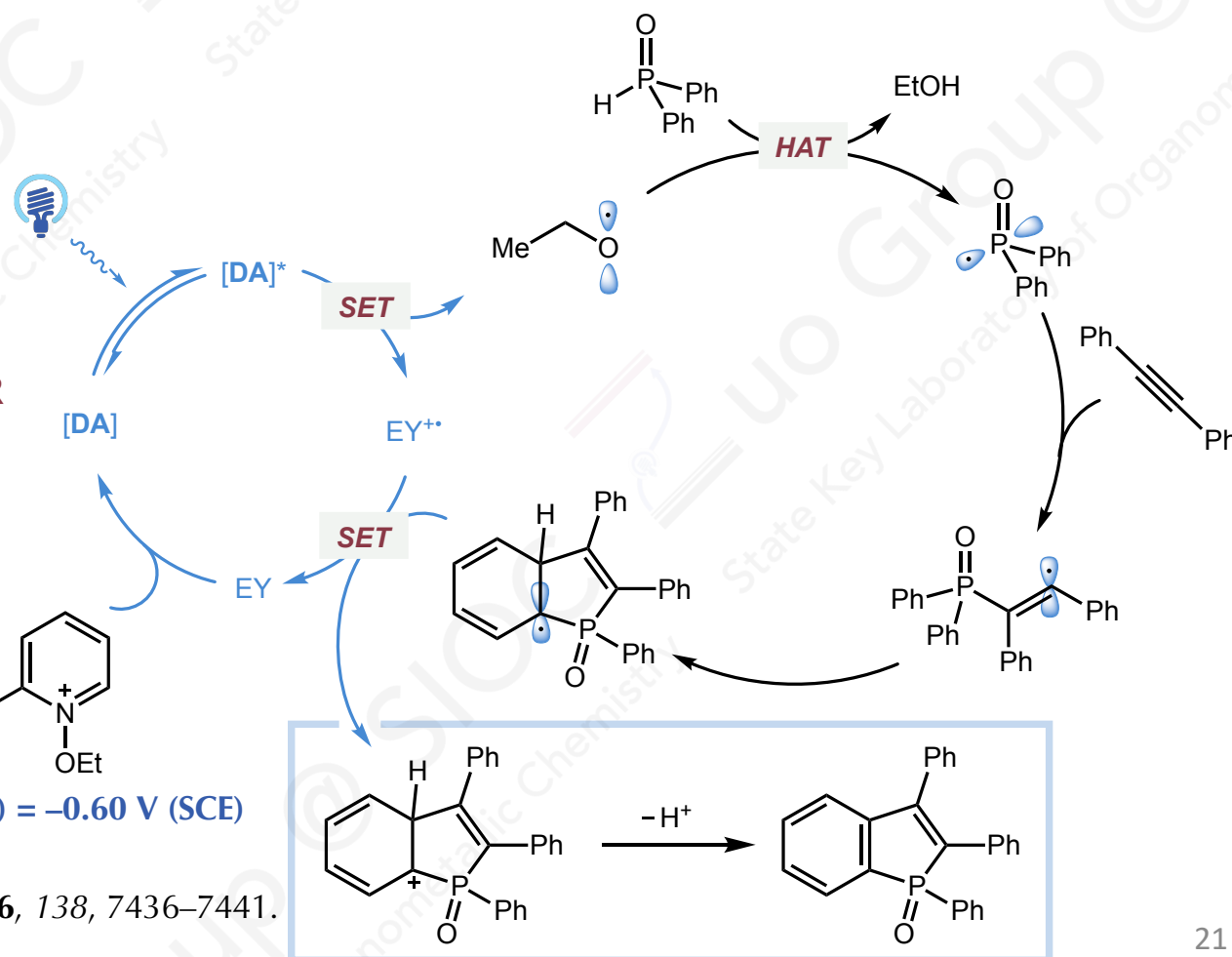
Catalytic EDA complex: Cyclization reaction



characterized by XRD, NMR

$E_{\text{red}}(\text{EY}) = -1.11 \text{ V (SCE)}$

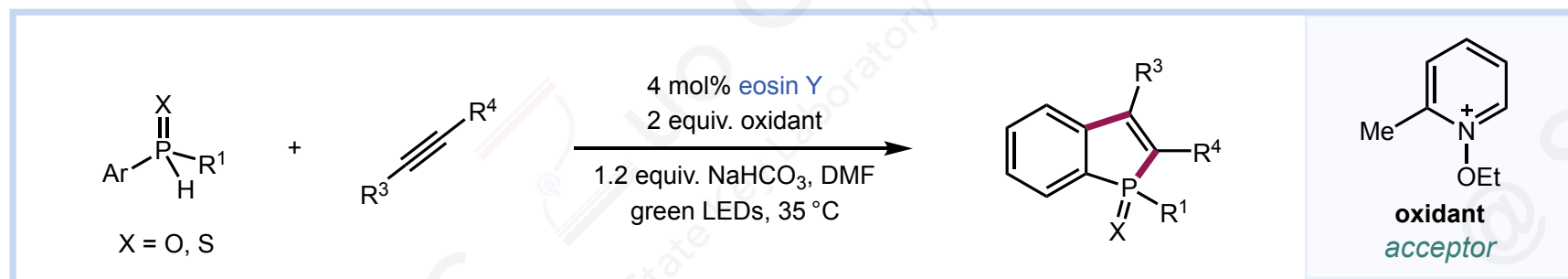
$E_{\text{red}}(\text{oxidant}) = -0.60 \text{ V (SCE)}$



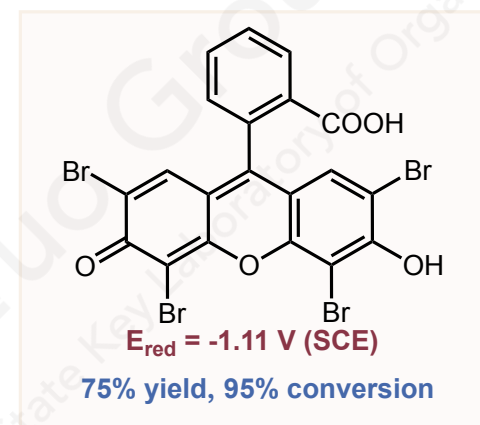
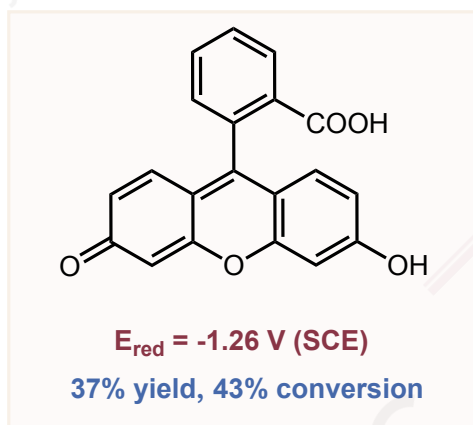
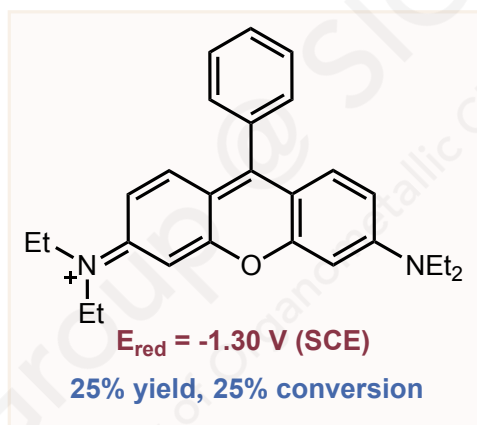
Lakhdar, S. et al. *J. Am. Chem. Soc.* **2016**, 138, 7436–7441.

Catalytic EDA complex: Cyclization reaction

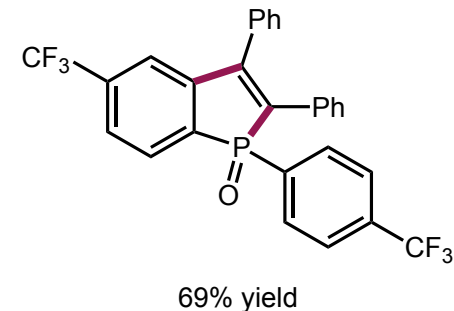
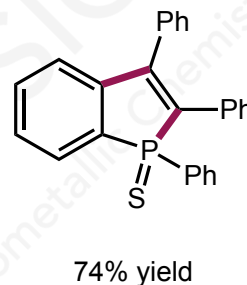
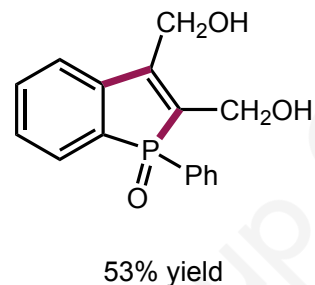
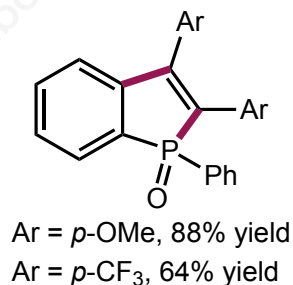
Visible Light-Photocatalyzed Synthesis of Benzo[b]phosphole Oxides



氧化电势对EDA复合物SET速率的影响

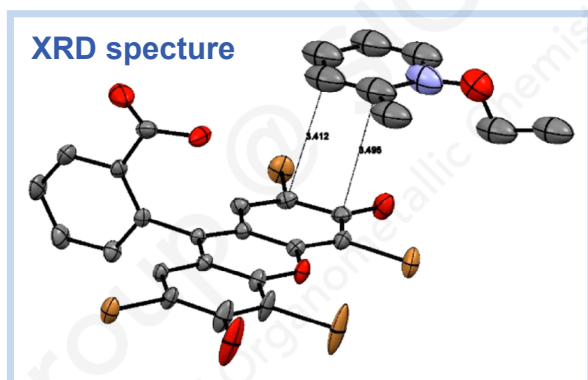
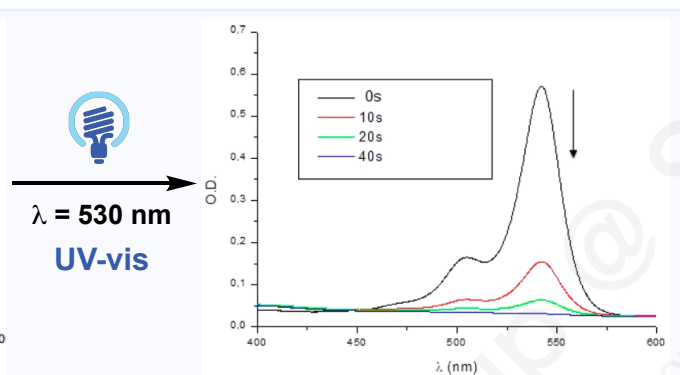
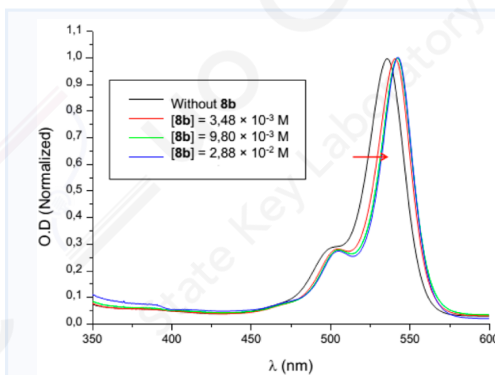
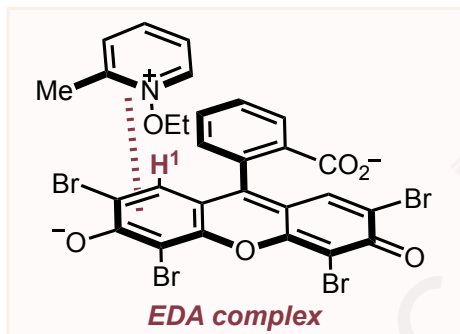


Scope of substrates



Catalytic EDA complex: Cyclization reaction

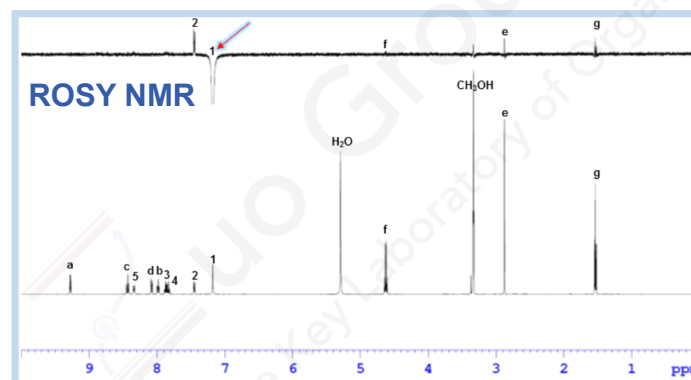
Mechanistic investigations of Electron transfer with EDA complex



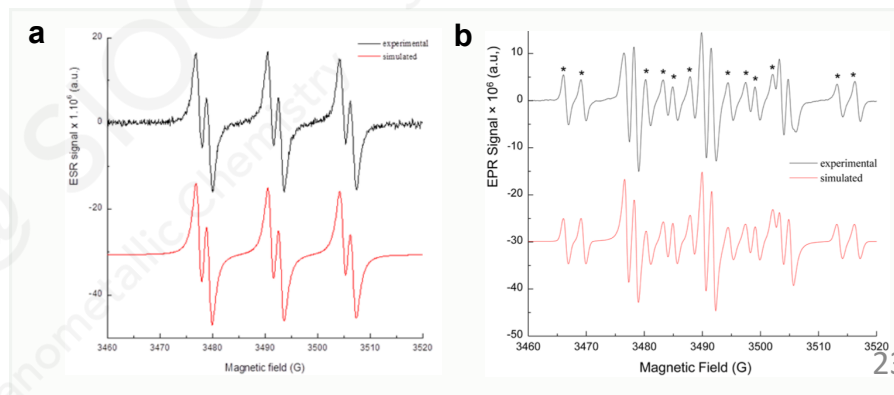
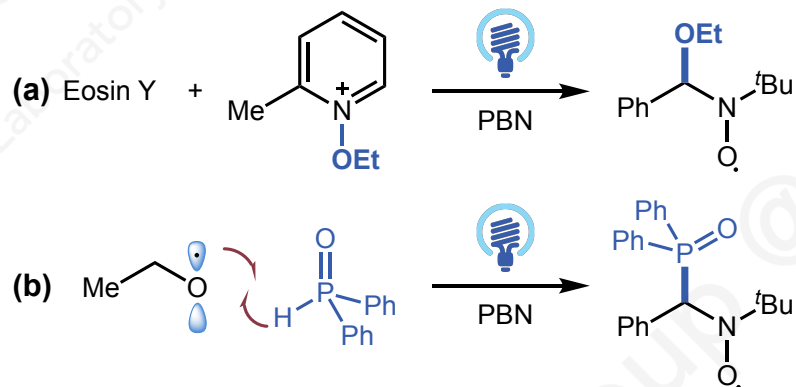
➤ EDA complex 吸收峰红移

➤ XRD: C1-C2 = 3.412 Å

➤ ROSY: H¹与OEt上H距离接近

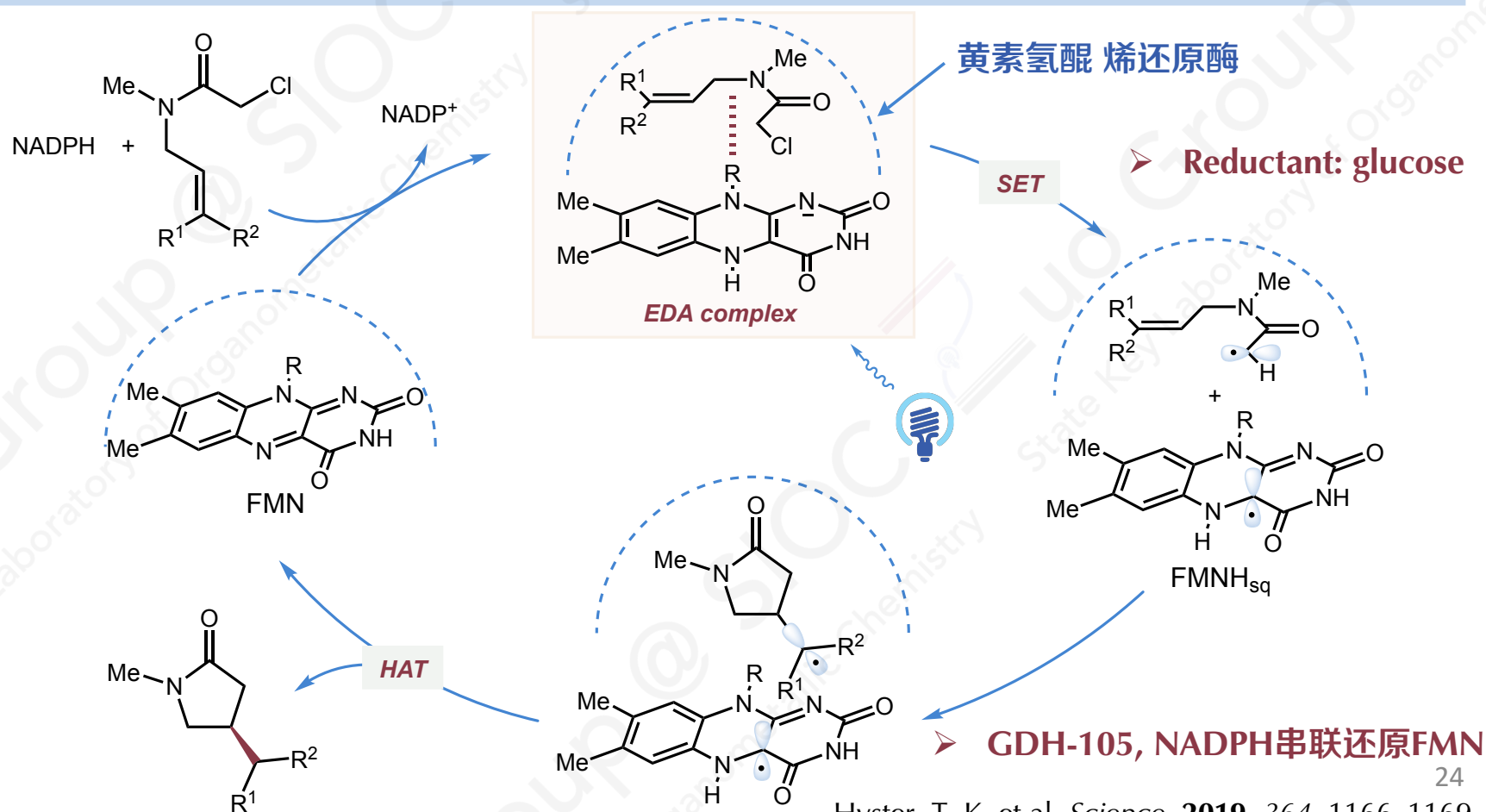
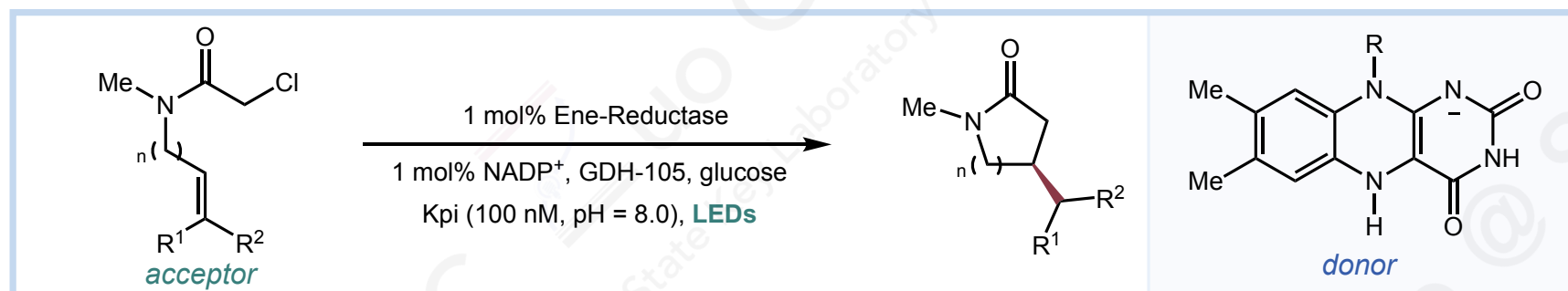


EPR spectre

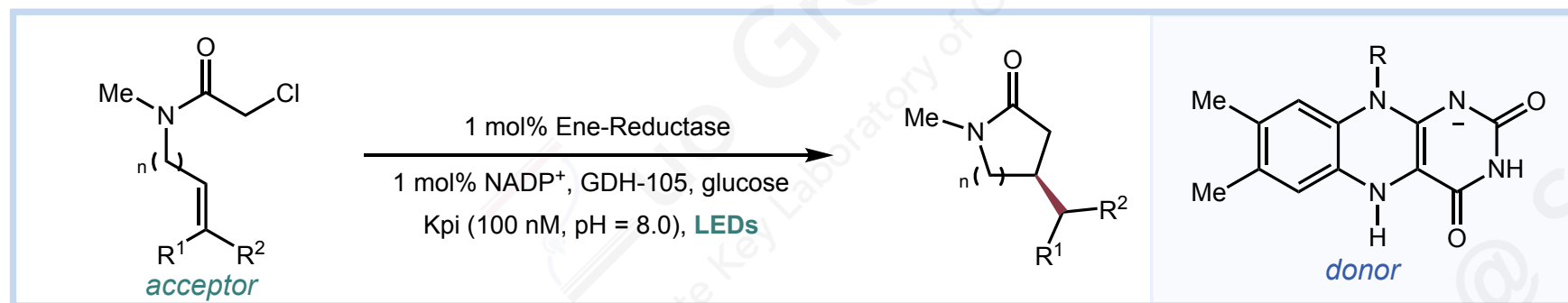


Catalytic EDA complex: Cyclization reaction

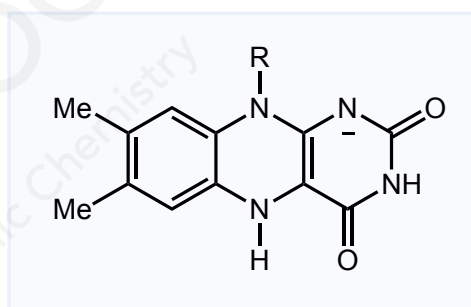
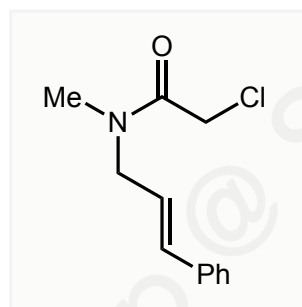
■ Photoexcitation of flavoenzymes enables a stereoselective radical cyclization



Catalytic EDA complex: Cyclization reaction



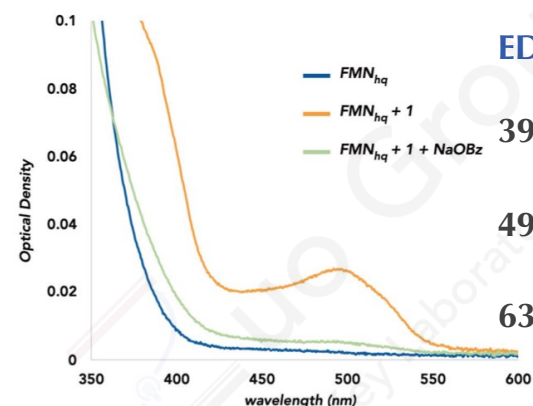
Thermodynamics



$$E_{\text{red}}(\text{acceptor}) = -1.65 \text{ V (SCE)}$$

$$E_{\text{red}}(\text{FMN}_{\text{hq}}) = -0.45 \text{ V (SCE)}$$

$$E_{\text{red}}(*\text{FMN}_{\text{hq}}) = -2.26 \text{ V (SCE)}$$



EDA band: 500 nm

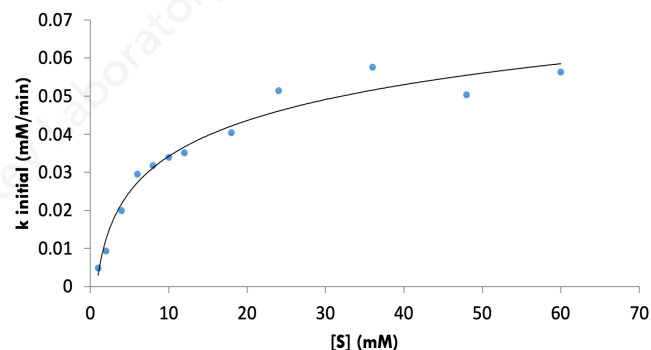
390 nm: 42% yield

490 nm: 68% yield

630 nm: 2% yield

Kinetics

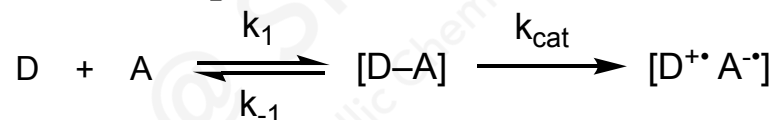
Initial Rates Plot



Michaelis-Menten kinetics: $K_M = 9.69 \text{ mM}$

$$K_M = \frac{k_{\text{cat}} + k_{-1}}{k_1}$$

EDA复合物平衡常数



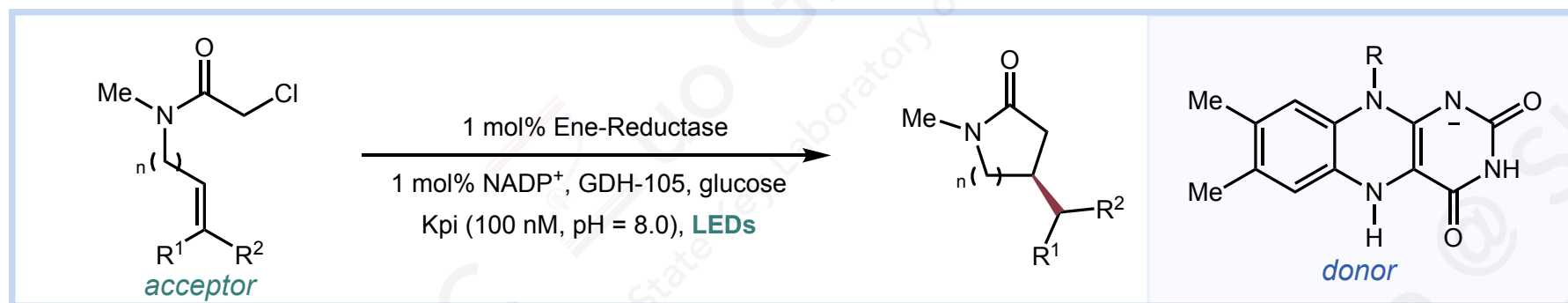
k_{cat} : EDA生成产物的表观一级速率常数

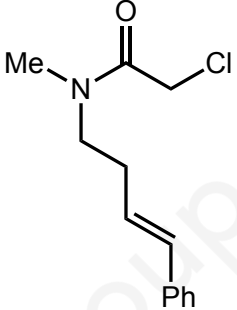
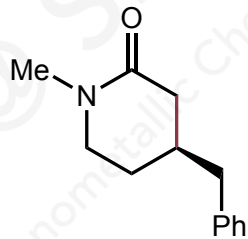
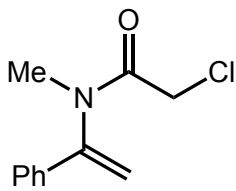
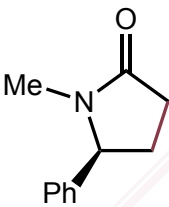
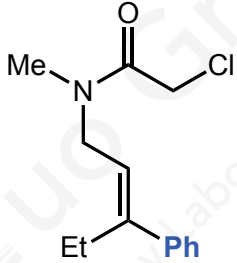
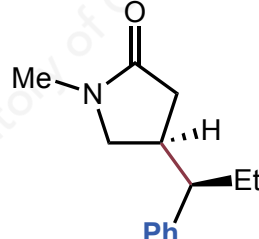
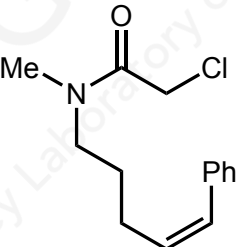
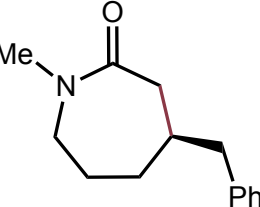
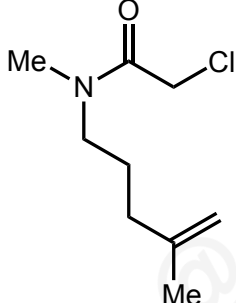
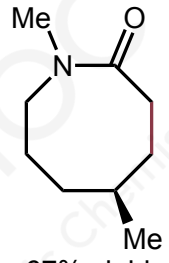
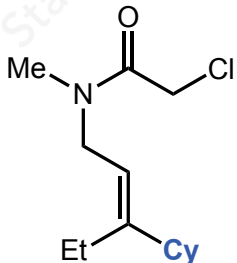
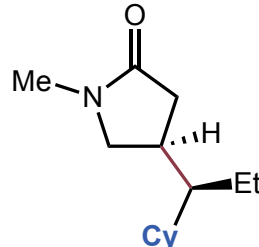
$$\frac{\text{Flux}_1}{\text{Flux}_2} \cong \frac{k_{\text{cat} 1}}{k_{\text{cat} 2}}$$

决速步具有光依赖性

Hyster, T. K. et al. *Science*. **2019**, 364, 1166–1169.

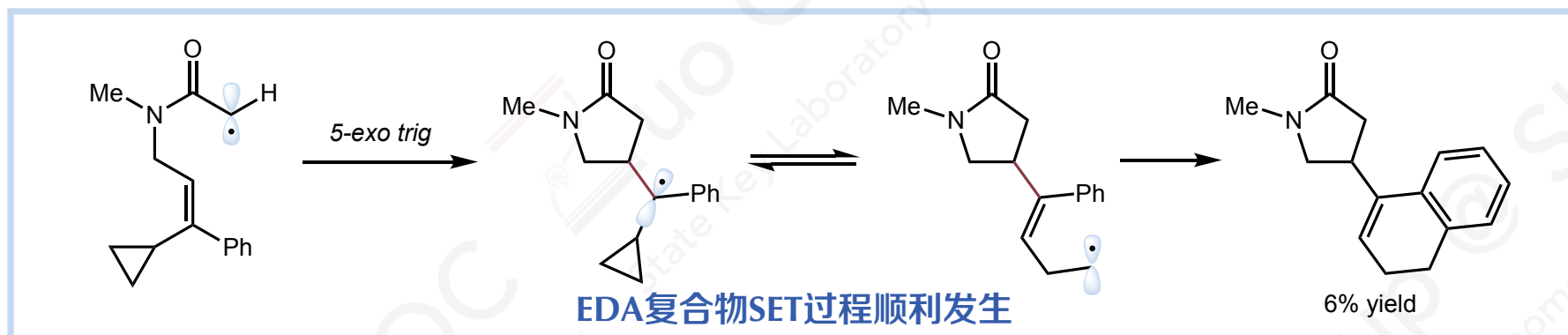
Catalytic EDA complex: Cyclization reaction



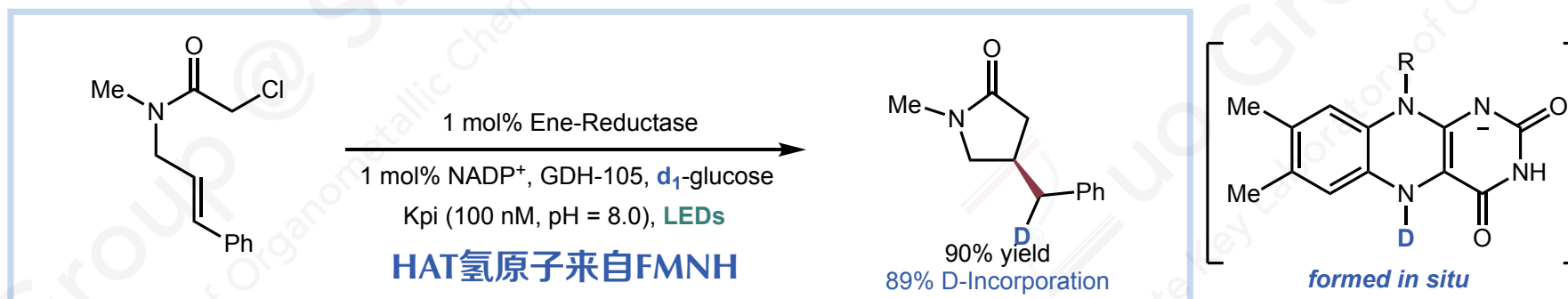
Starting material	Product	Starting material	Product	Starting material	Product
 6-exo	 44% yield 86:14 er	 5-endo	 51% yield 93:7 er	 Ph	 67% yield 95:5 er, 87:13 dr
 7-exo	 87% yield 90:10 er	 8-endo	 67% yield 83:17 er	 Cy	 84% yield 99:1 er, 79:21 dr

Catalytic EDA complex: Cyclization reaction

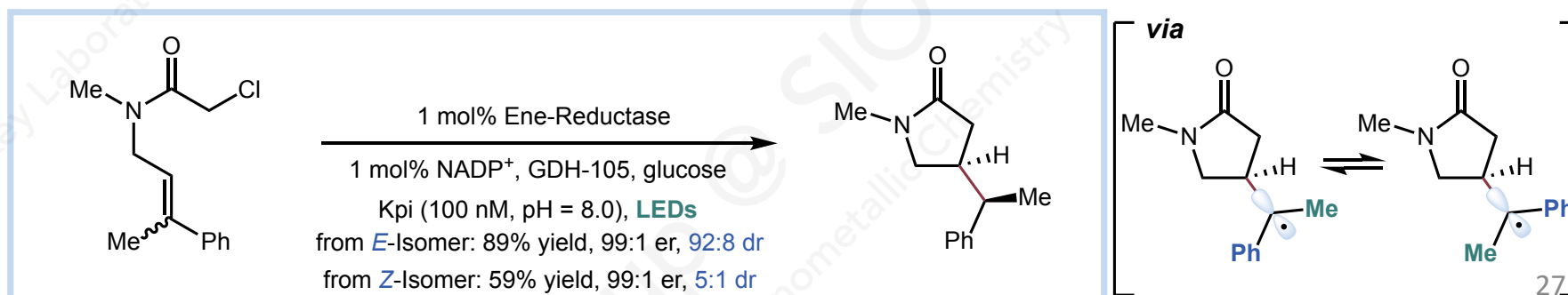
Radical clock



Isotope labeling

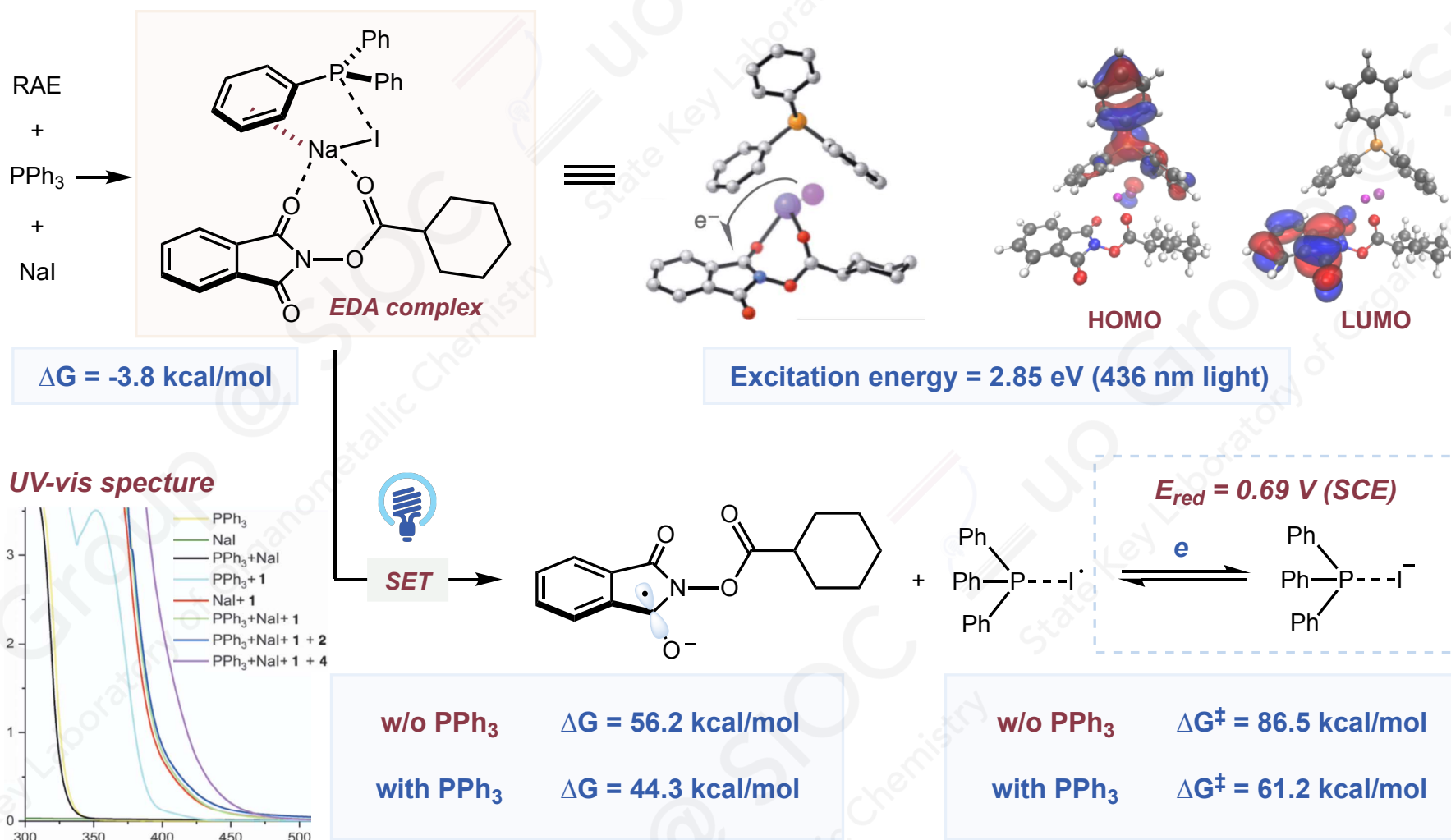


Conformation-selective HAT



Catalytic EDA complex: C–C Bond formation

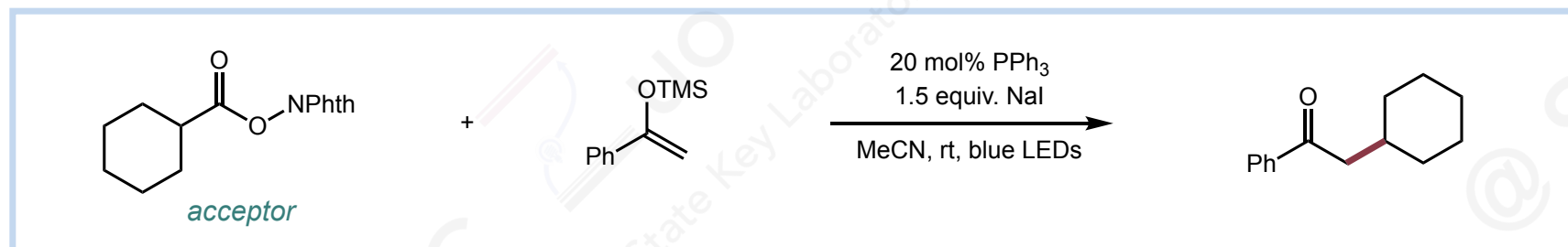
■ Decarboxylative alkylations mediated by triphenylphosphine and sodium iodide



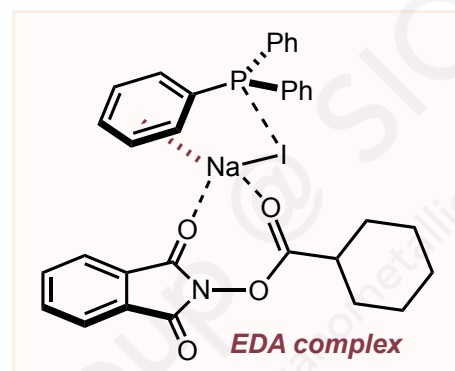
Fu, Y. et al. *Science*. **2019**, 363, 1429–1434.

Catalytic EDA complex: C–C Bond formation

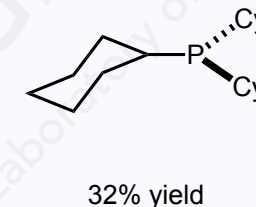
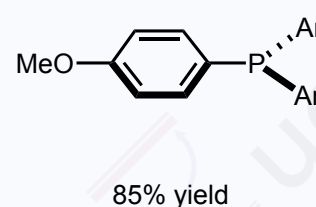
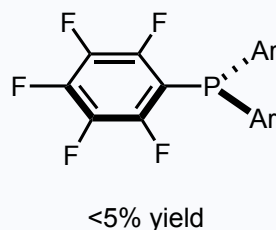
Decarboxylative alkylations mediated by triphenylphosphine and sodium iodide



氧化电势对EDA复合物电子转移速率的影响



donor



EDA band

$\lambda = 520 \text{ nm}$	<5% yield
$\lambda = 440 \text{ nm}$	81% yield
$\lambda = 365 \text{ nm}$	36% yield

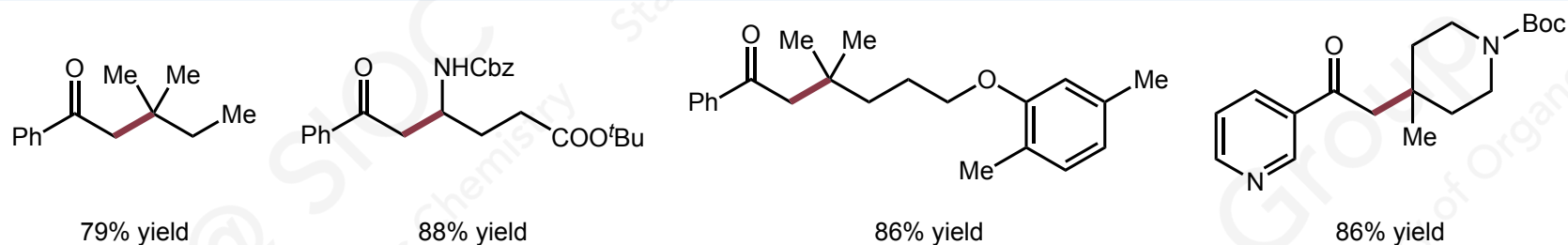
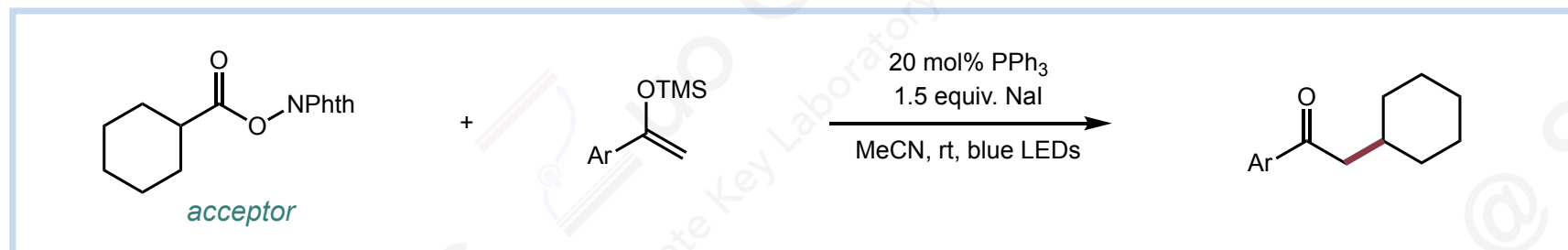
EDA复合物稳定性对反应的影响

NaI	LiI	KI	$n\text{-Bu}_4\text{NI}$
82% yield	74% yield	50% yield	<1% yield
$\Delta G = -3.8 \text{ kcal/mol}$	$\Delta G = -1.1 \text{ kcal/mol}$	$\Delta G = -2.9 \text{ kcal/mol}$	

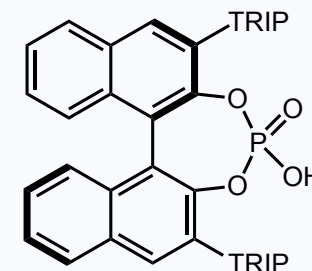
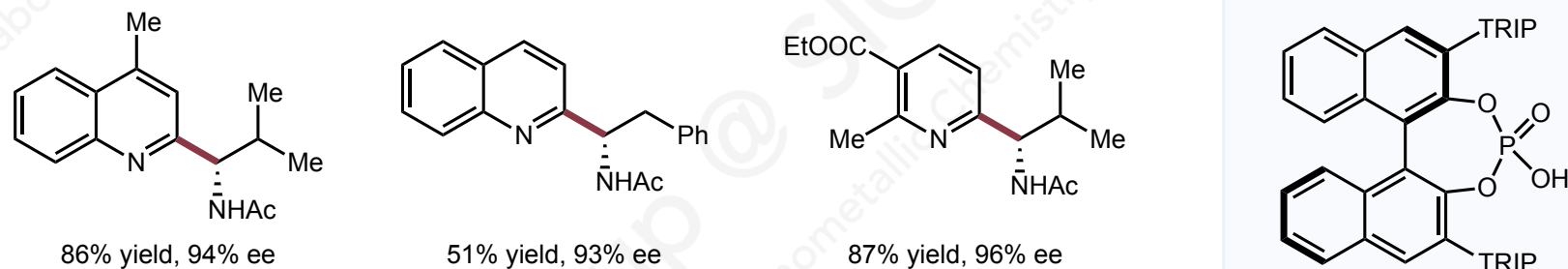
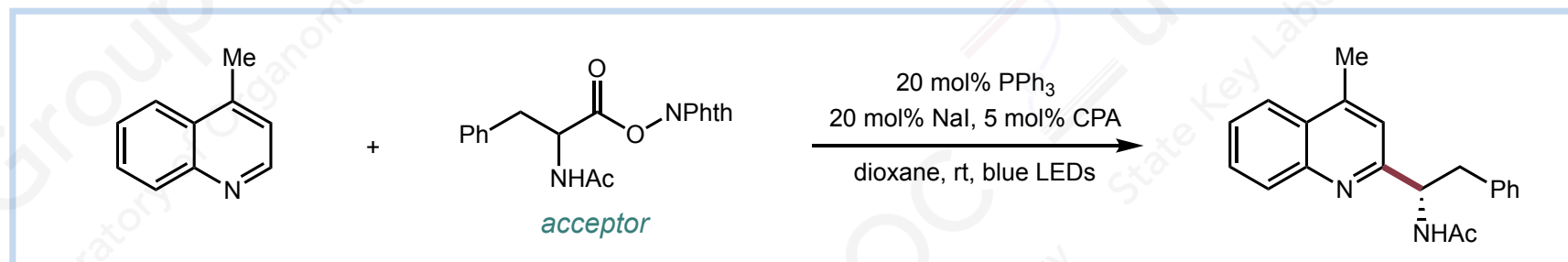
Fu, Y. et al. *Science*. **2019**, 363, 1429–1434.

Catalytic EDA complex: C–C Bond formation

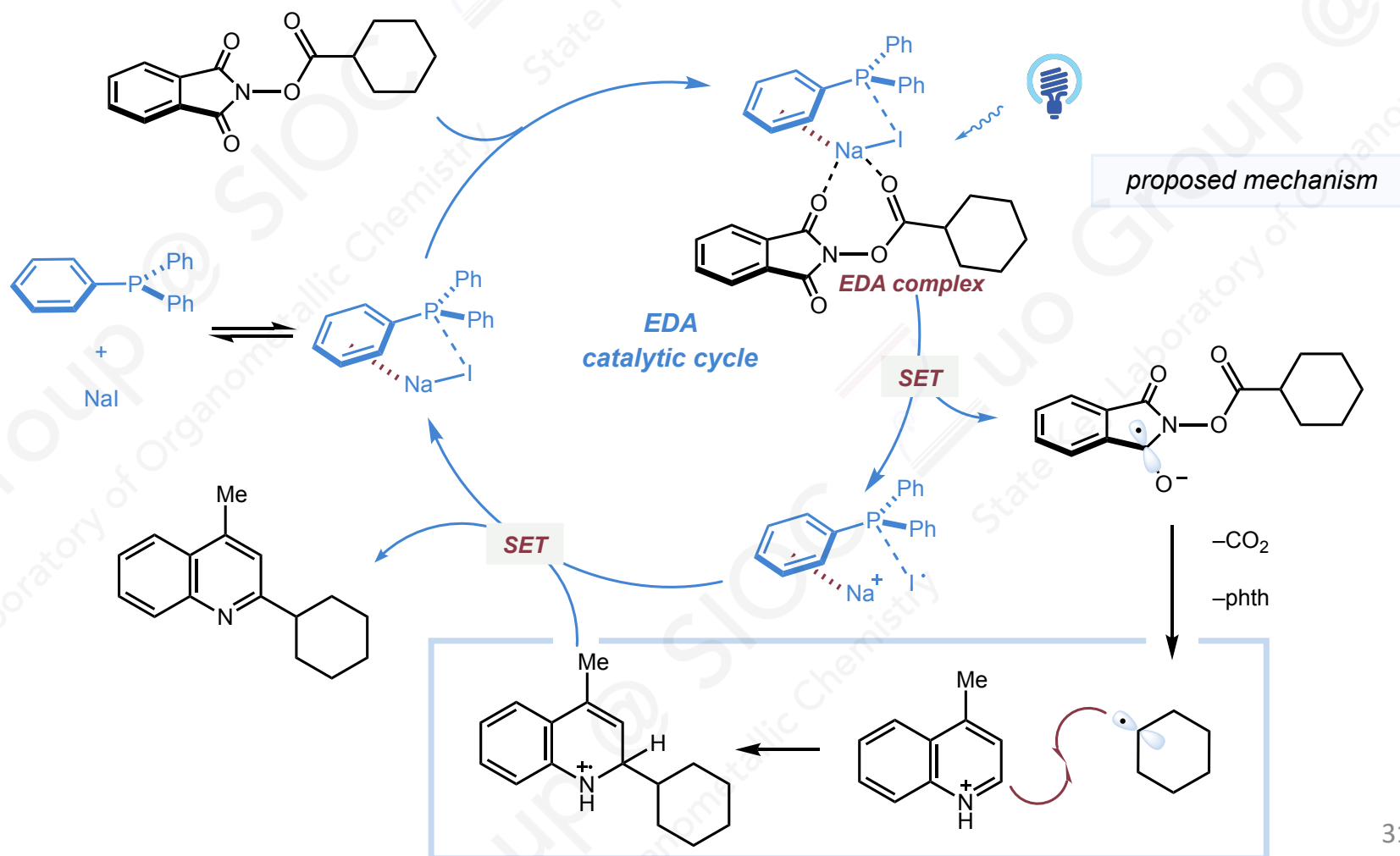
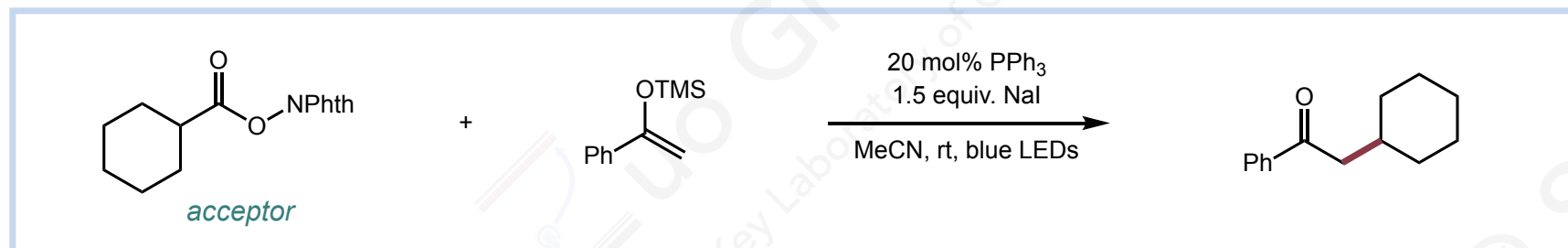
■ Decarboxylative alkylation of silyl enol ether



■ Minisci-type decarboxylative alkylation

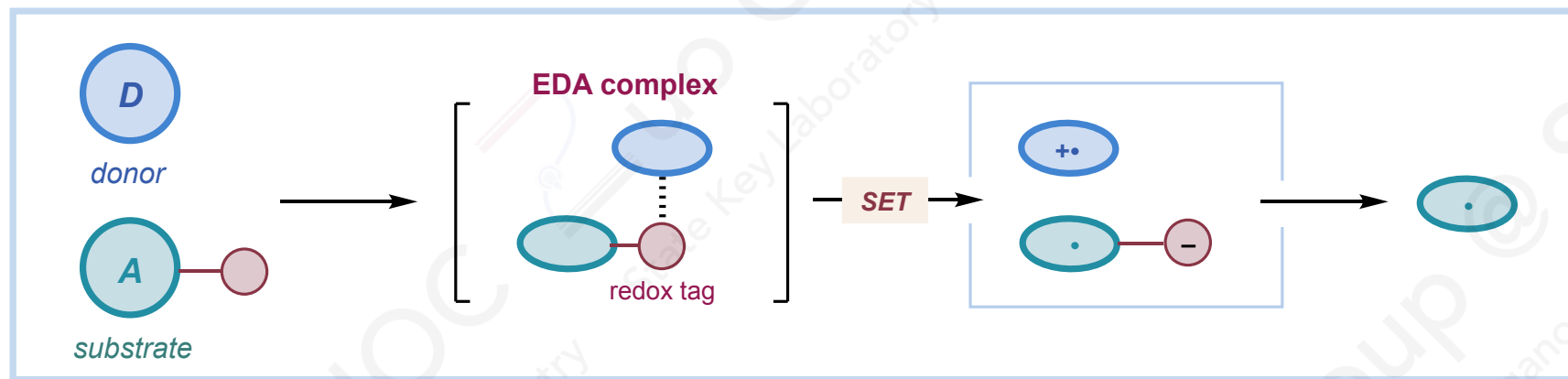


Catalytic EDA complex: C–C Bond formation



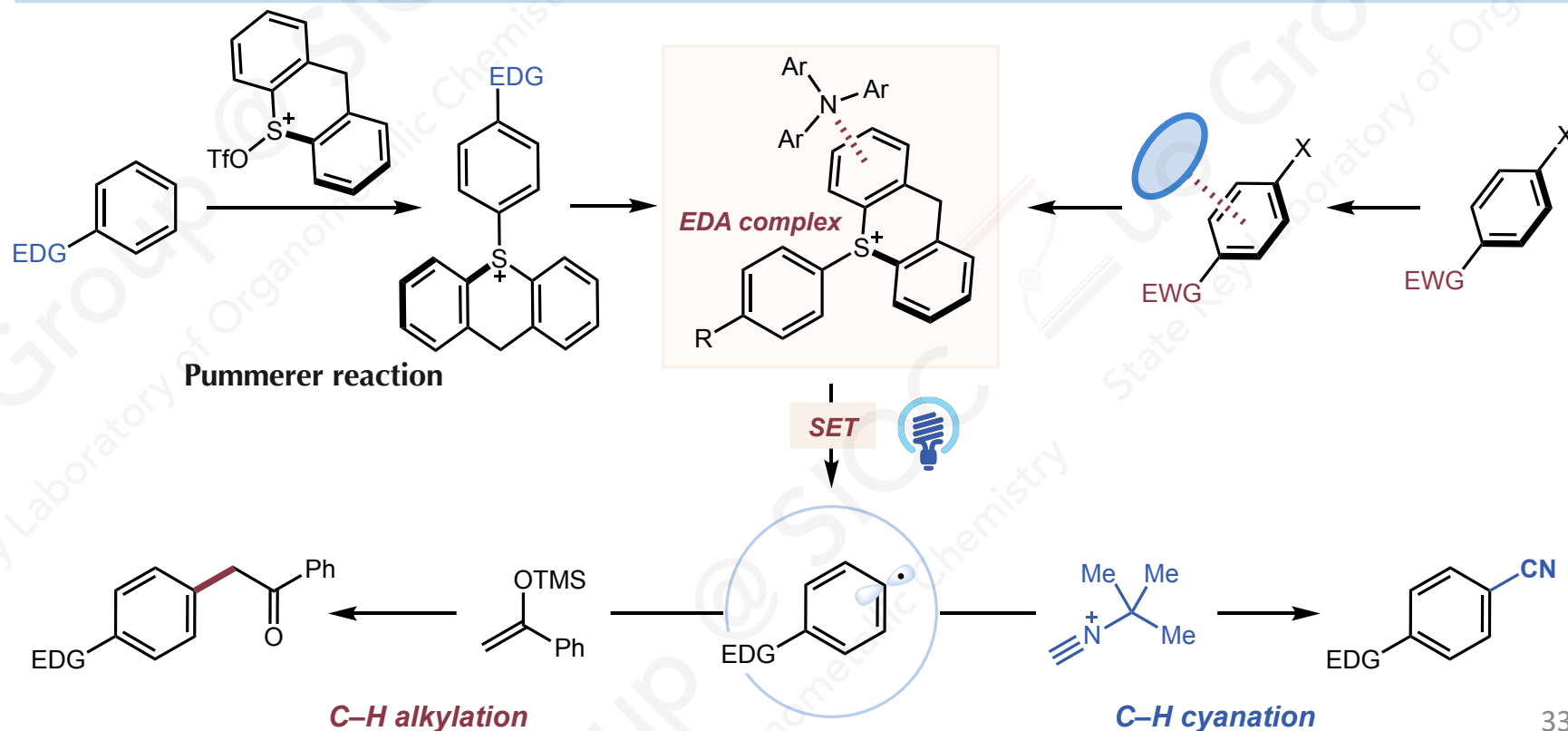
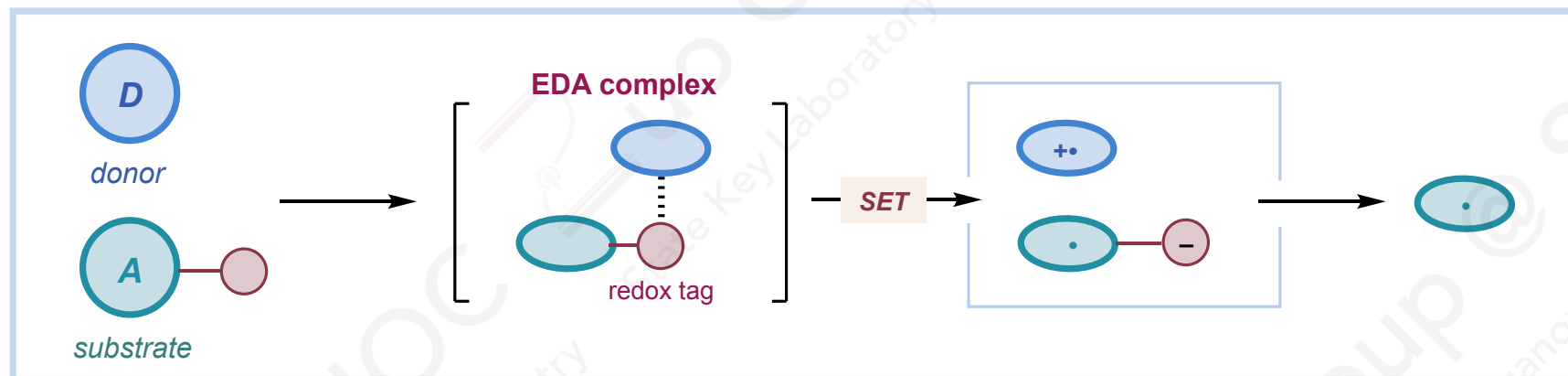
Catalytic EDA complex: C–C Bond formation

■ Arene C–H functionalization strategy via electron donor–acceptor complex

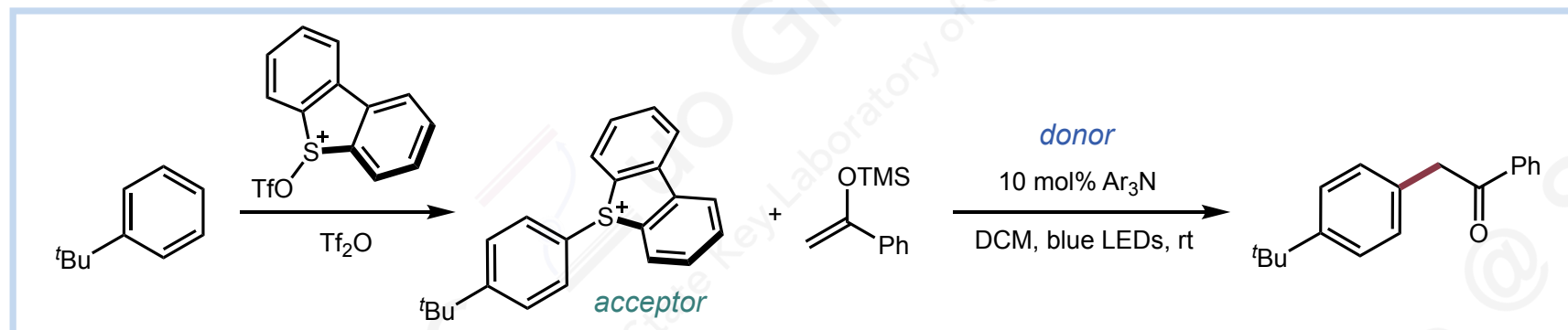


Catalytic EDA complex: C–C Bond formation

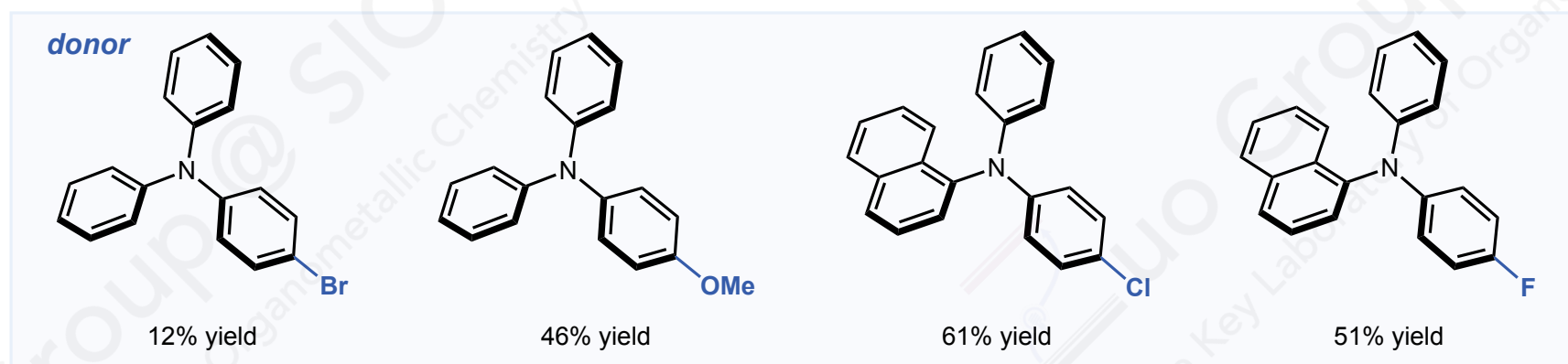
■ Arene C–H functionalization strategy via electron donor–acceptor complex



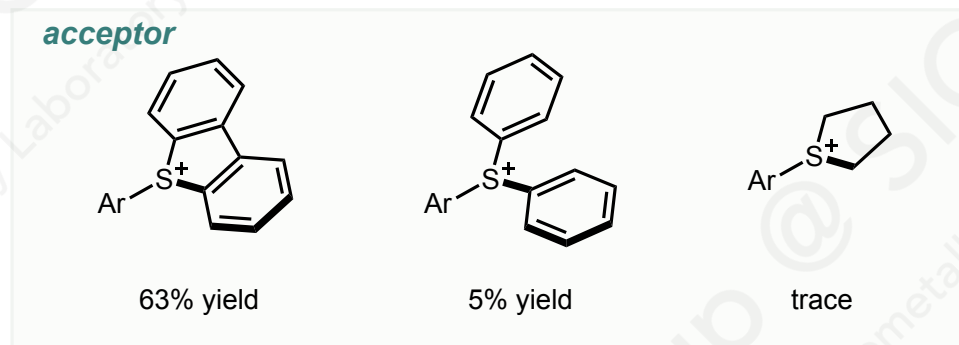
Catalytic EDA complex: C–C Bond formation



■ 供体还原电势对EDA电子转移的影响



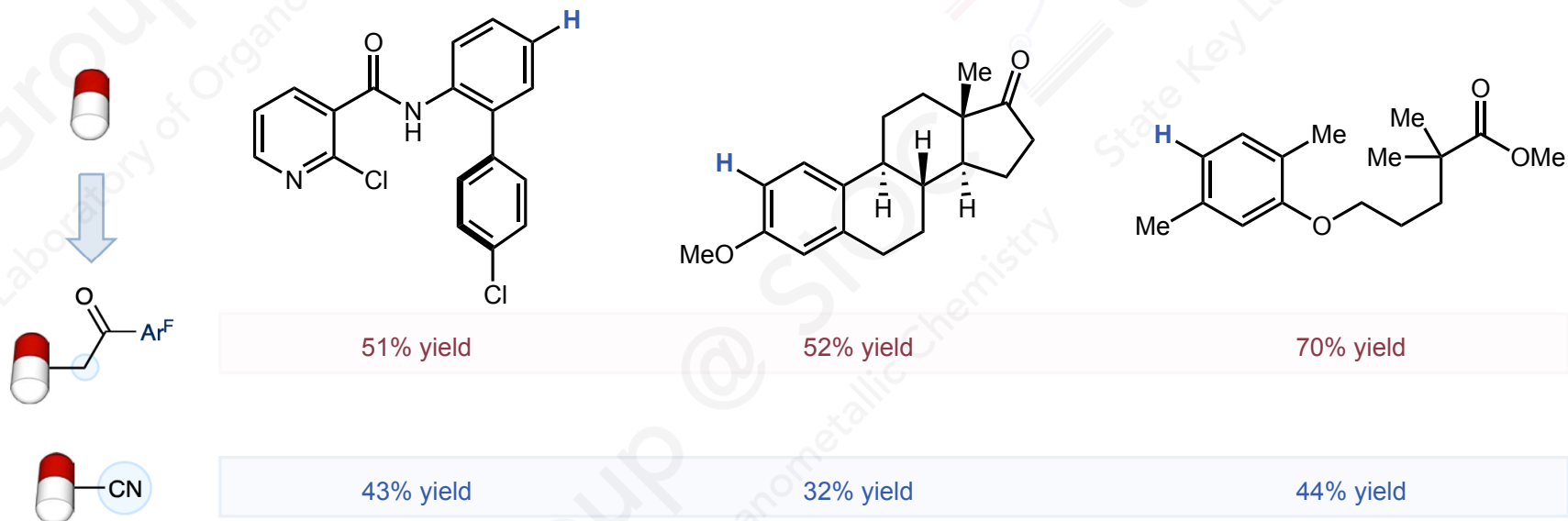
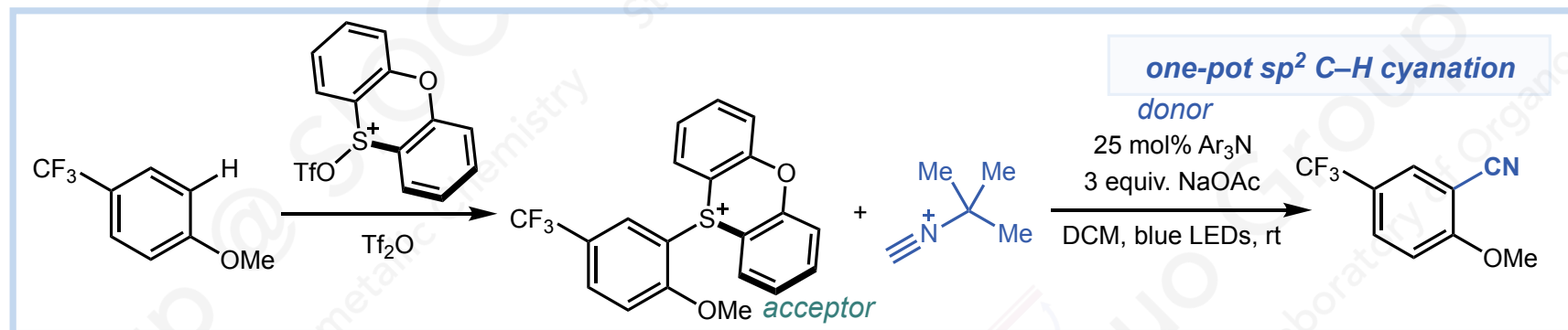
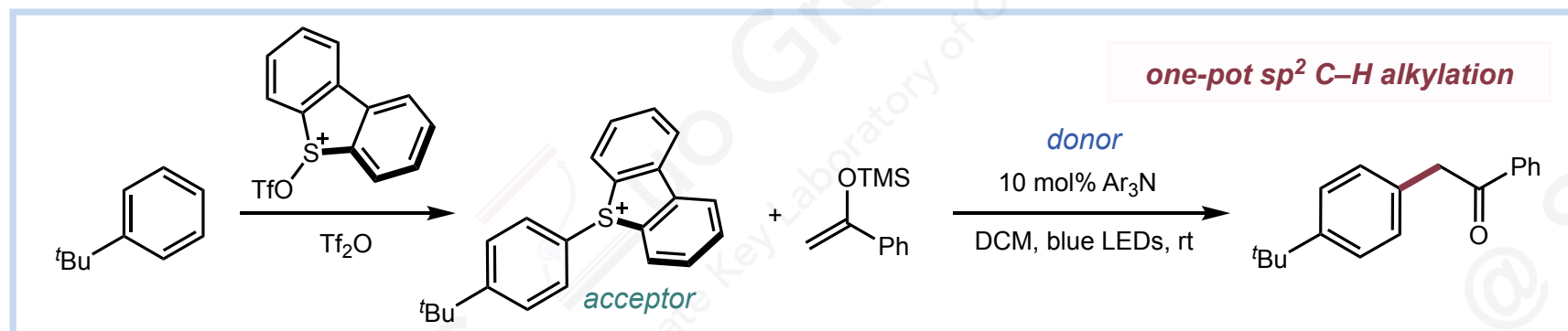
■ 受体共轭体系对EDA电子转移的影响



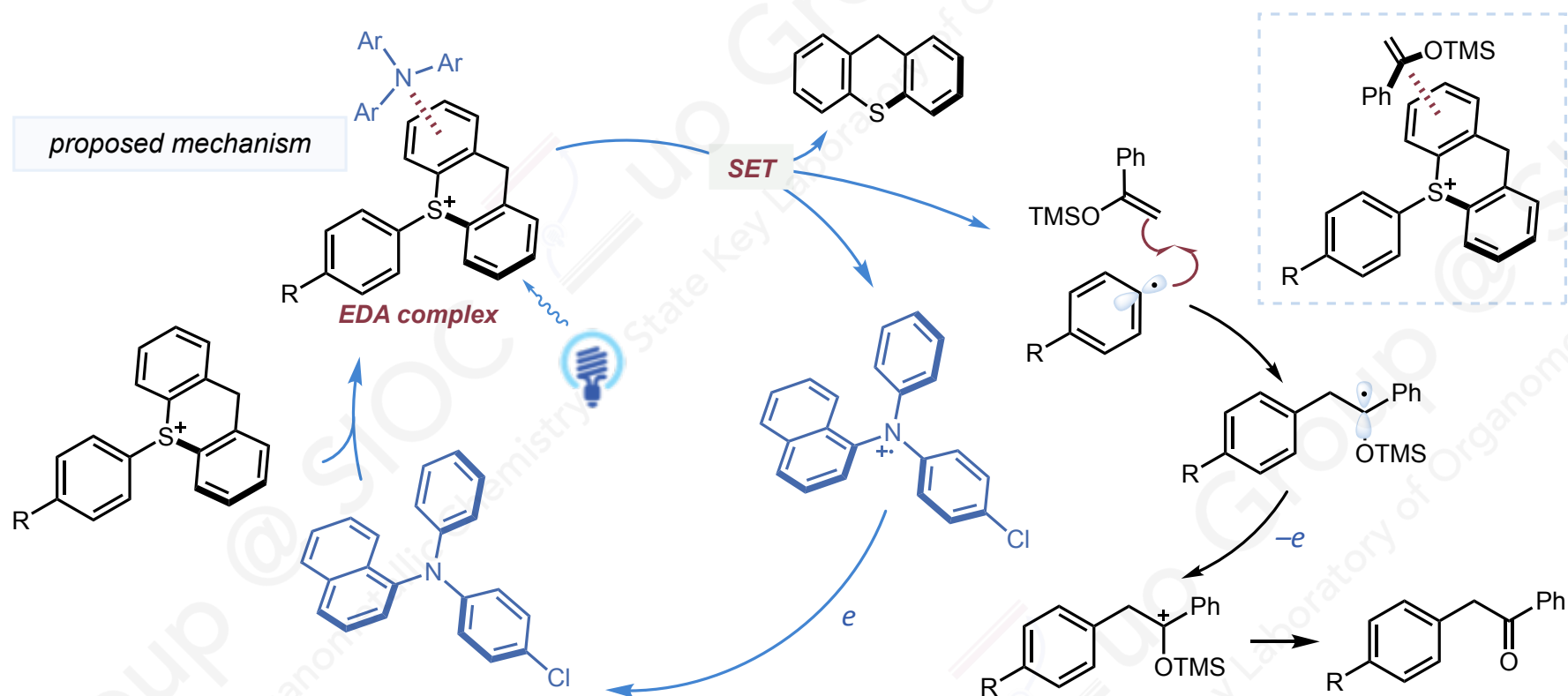
■ EDA band对电子转移的影响

$\lambda = 390 \text{ nm}$, w/o donor	40% yield
$\lambda = 456 \text{ nm}$, w/o donor	34% yield
$\lambda = 456 \text{ nm}$, with donor	63% yield
dark, 60 °C	0% yield

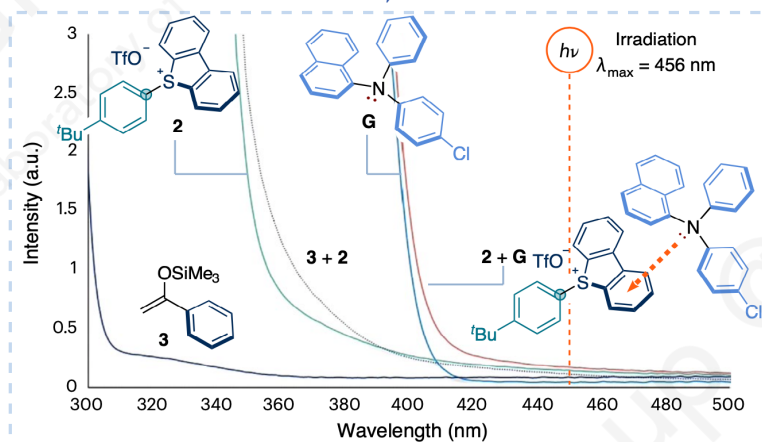
Catalytic EDA complex: C–C Bond formation



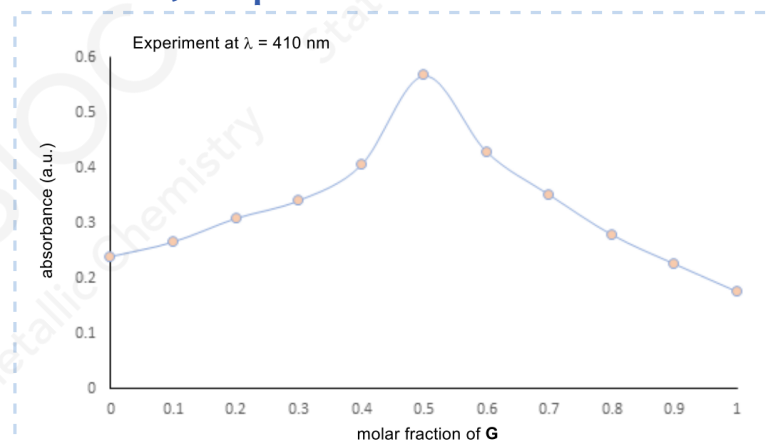
Catalytic EDA complex: C–C Bond formation



► EDA band: $\lambda = 440$ nm, 烯炔也可能作为电子供体

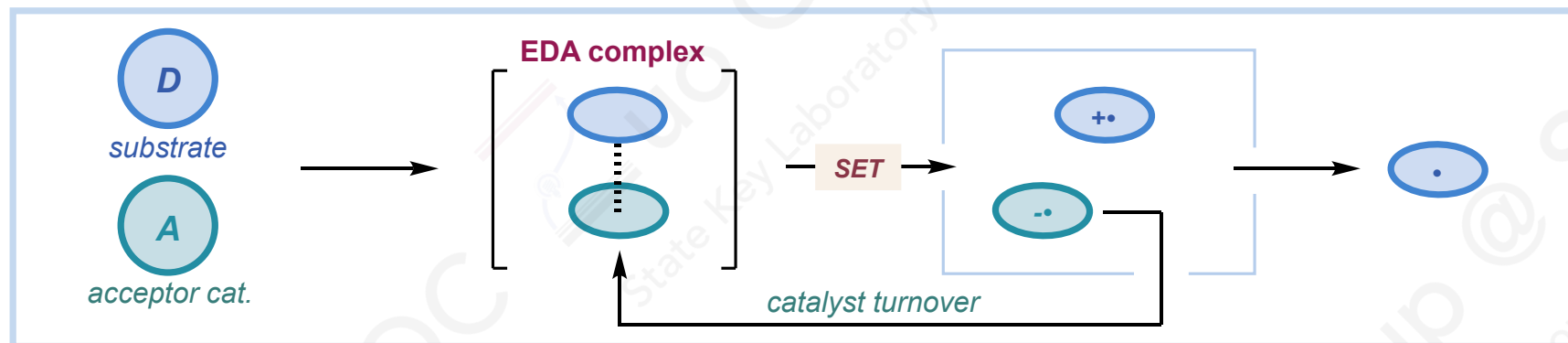


► Job's plot: EDA复合物比例为1:1



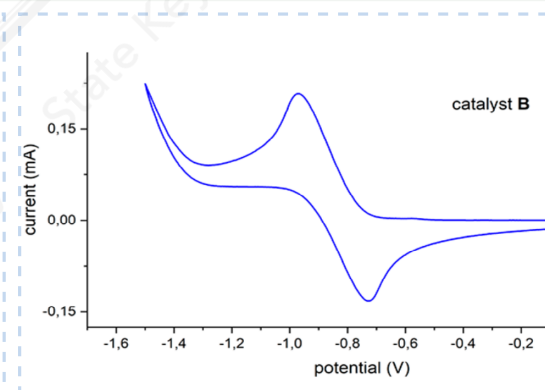
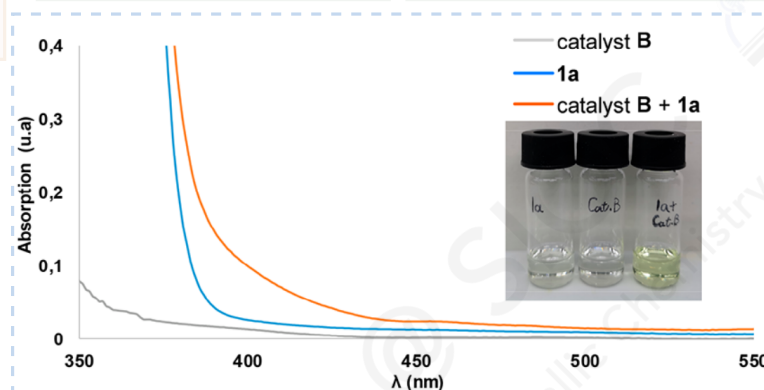
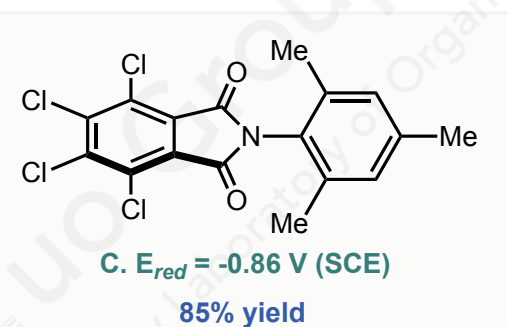
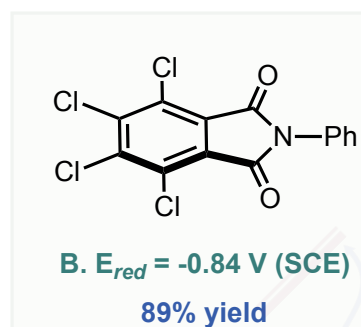
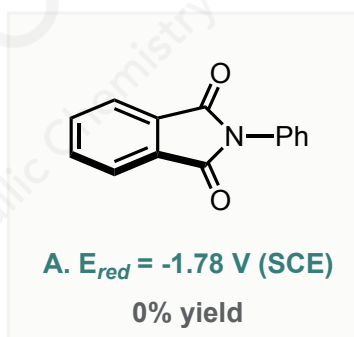
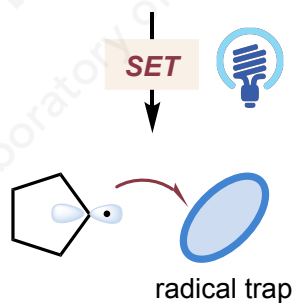
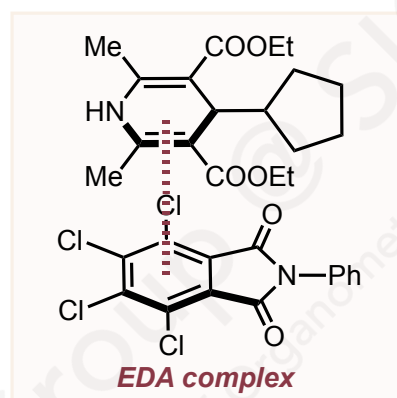
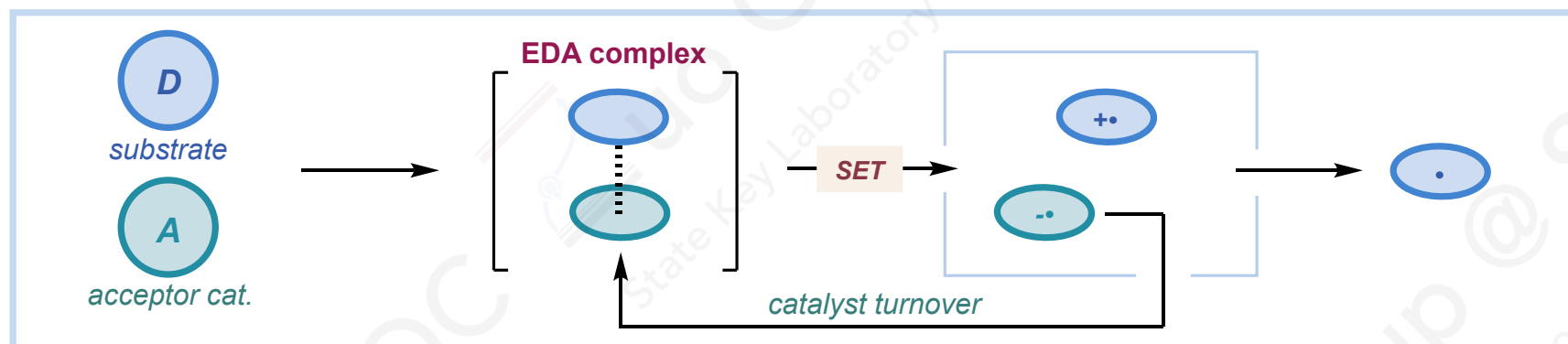
Catalytic EDA complex: C=C Bond formation

■ *Tetrachlorophthalimides as Organocatalytic Acceptors for EDA complex Photoactivation*



Catalytic EDA complex: C=C Bond formation

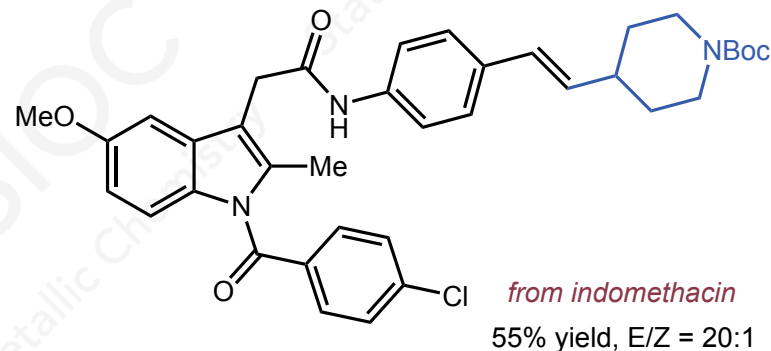
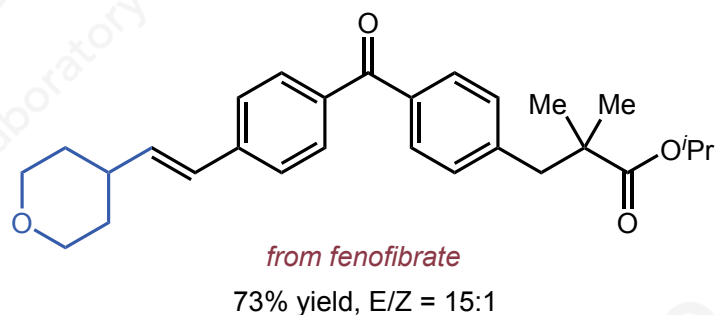
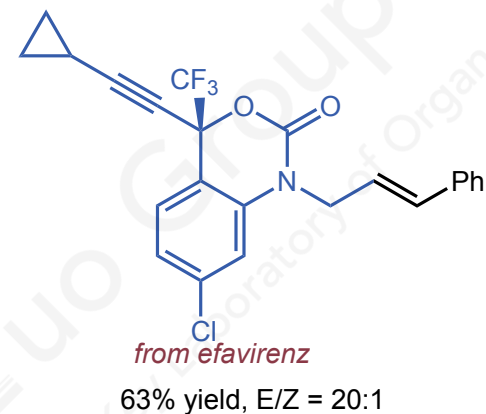
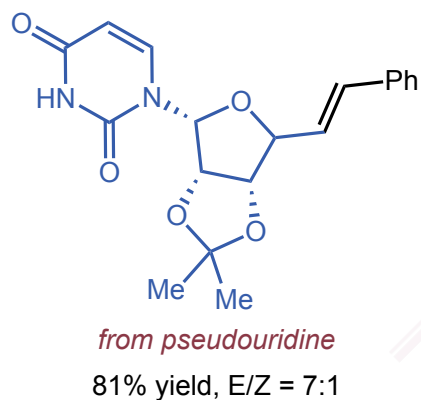
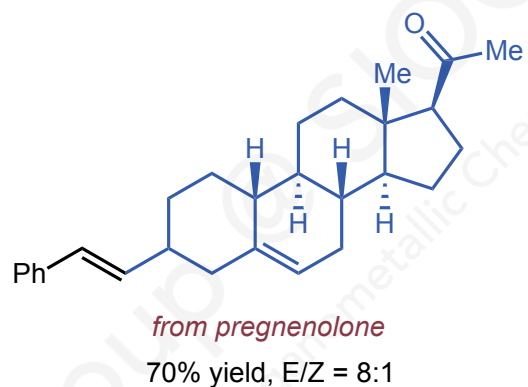
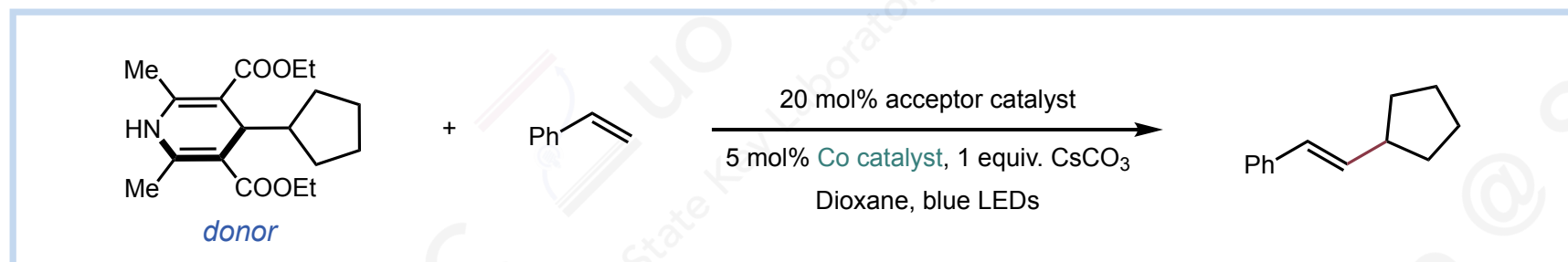
■ Tetrachlorophthalimides as Organocatalytic Acceptors for EDA complex Photoactivation



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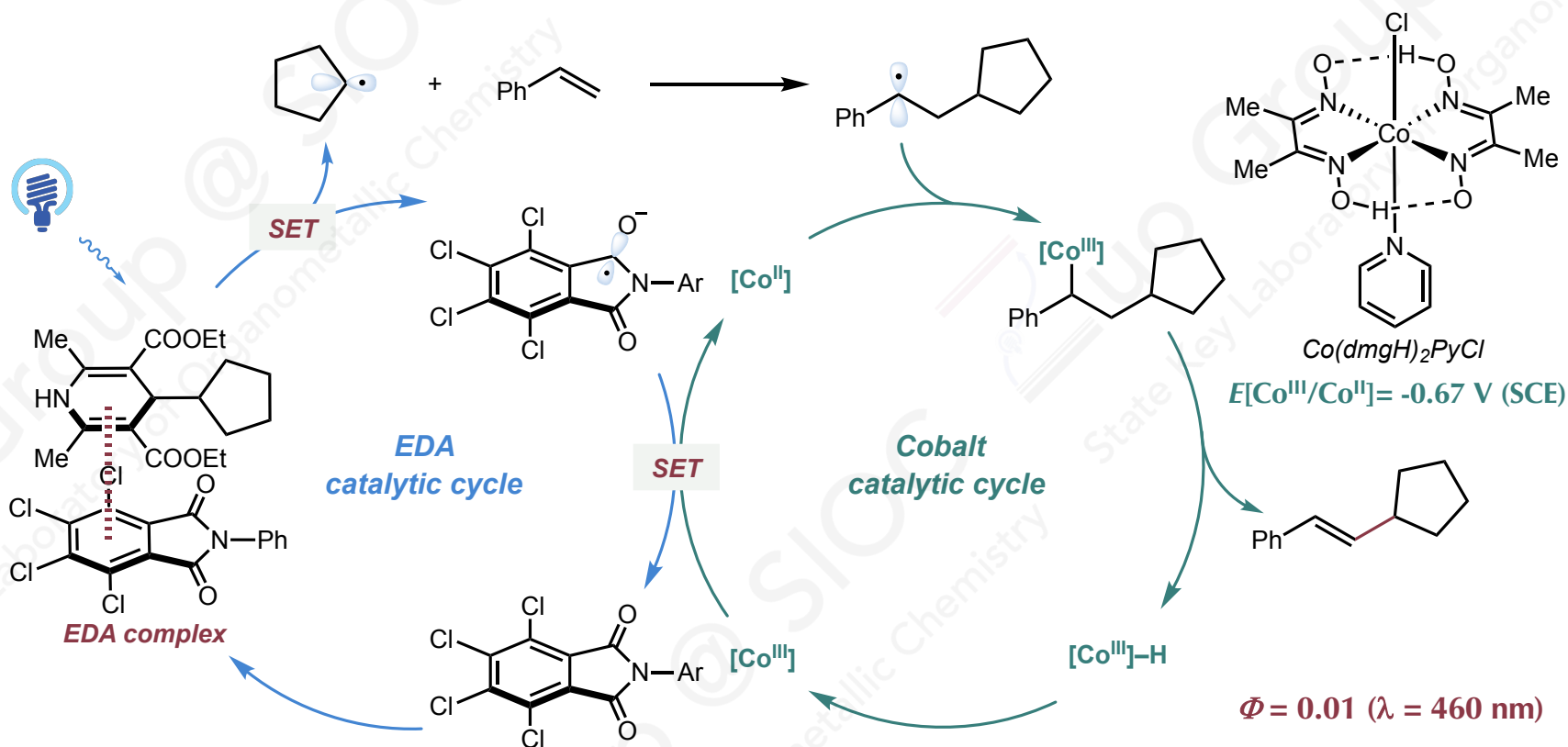
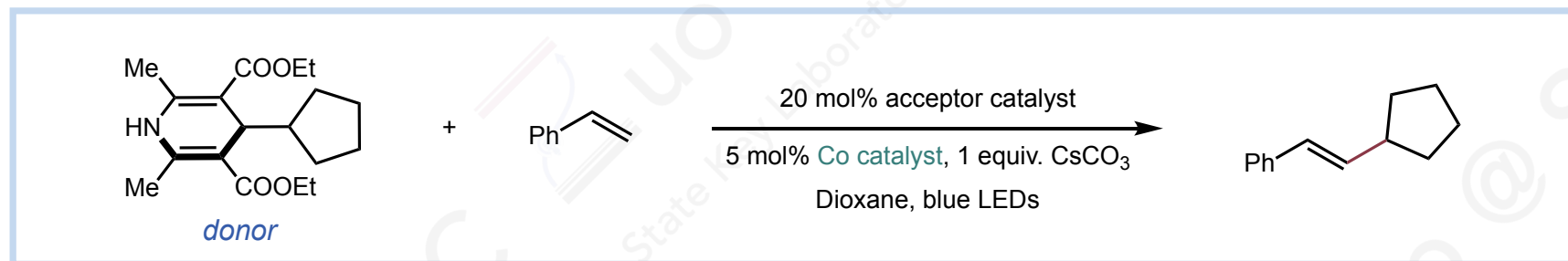
Catalytic EDA complex: C=C Bond formation

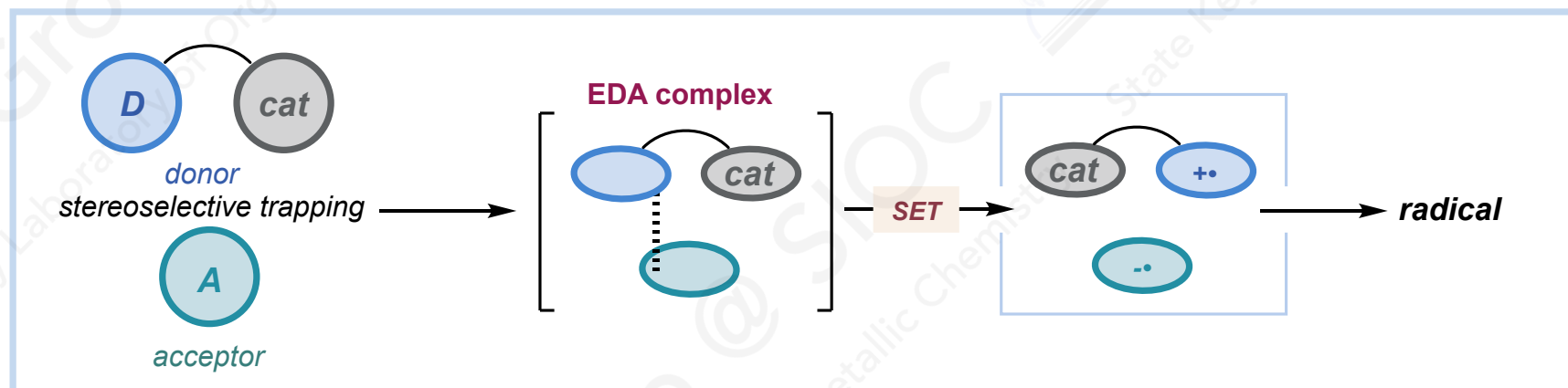
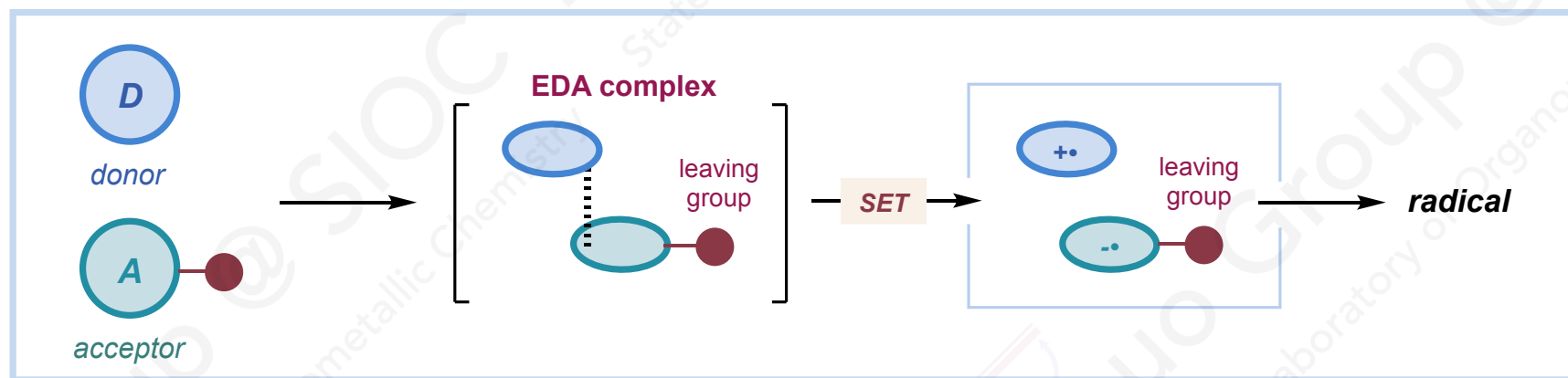
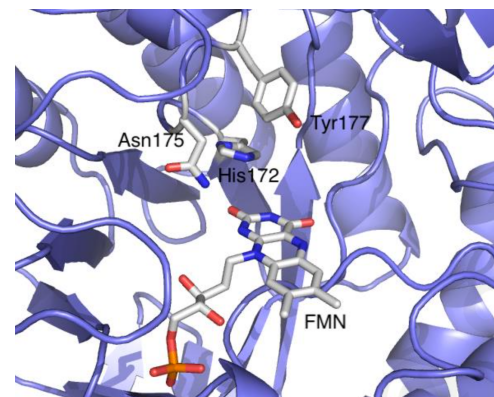
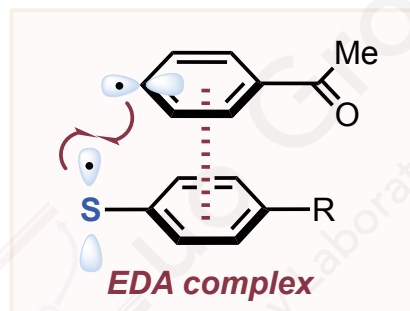
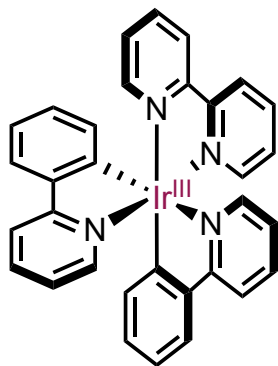
■ Tetrachlorophthalimides as Organocatalytic Acceptors for EDA complex Photoactivation



Catalytic EDA complex: C=C Bond formation

Tetrachlorophthalimides as Organocatalytic Acceptors for EDA complex Photoactivation





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